

AD-A058 093

AIR FORCE WEAPONS LAB KIRTLAND AFB N MEX

F/6 9/5

COMPARISON STUDY OF THE FIVE TRANSISTOR-TRANSISTOR-LOGIC (TTL) --ETC(U)

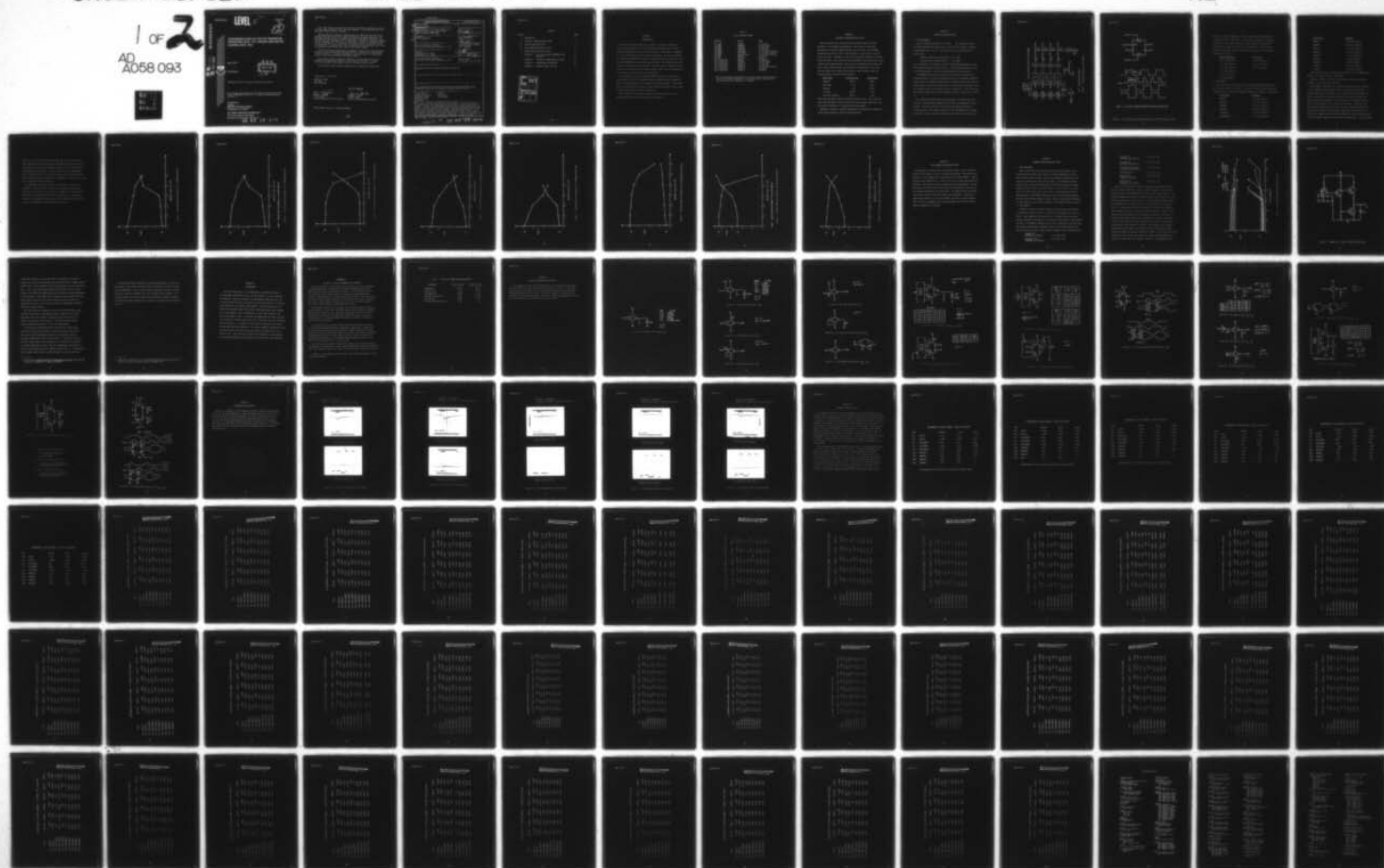
MAY 78 M G KNOLL

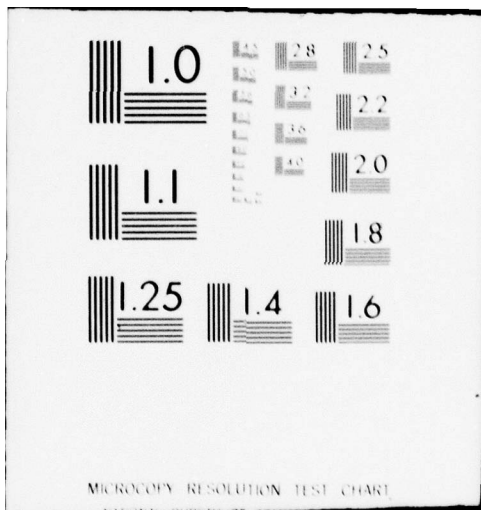
UNCLASSIFIED

AFWL-TR-78-5

NL

1 OF 2  
AD-A058 093





**LEVEL** *II*

*(12)*

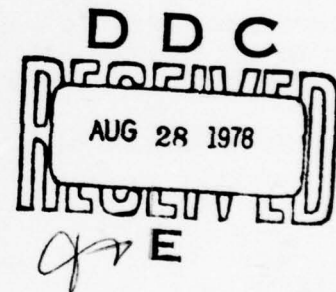
AD No. \_\_\_\_\_  
AD A 058093  
DDC FILE COPY



**COMPARISON STUDY OF THE FIVE TRANSISTOR-LOGIC (TTL) FAMILIES AND EMIT COUPLED LOGIC (ECL)**

May 1978

Final Report



Approved for public release; distribution unlimited.

This research was sponsored by the Defense Nuclear Agency under Subtask Z99QAXTB029, Work Unit 62, Radiation Characterization of MSI/LSI.

Prepared for  
Director  
DEFENSE NUCLEAR AGENCY  
Washington, DC 20305

AIR FORCE WEAPONS LABORATORY  
Air Force Systems Command  
Kirtland Air Force Base, NM 87117

78 07 27 03 8

This final report was prepared by the Air Force Weapons Laboratory, Kirtland Air Force Base, New Mexico under Job Order WDNE2001. Lt Michael Knoll was the Laboratory Project Officer-in-Charge.

When US Government drawings, specifications, or other data are used for any purpose other than a definitely related Government procurement operation, the Government thereby incurs no responsibility nor any obligation whatsoever, and the fact that the Government may have formulated, furnished or in any way supplied the said drawings, specifications, or other data, is not to be regarded by implication or otherwise, as in any manner licensing the holder or any other person or corporation, or conveying any rights or permission to manufacture, use, or sell any patented invention that may in any way be related thereto.

This report has been authored by an employee of the United States Government. Accordingly, the United States Government retains a nonexclusive, royalty-free license to publish or reproduce the material contained herein, or allow others to do so, for the United States Government purposes.

This report has been reviewed by the Office of Information (OI) and is releasable to the National Technical Information Service (NTIS). At NTIS, it will be available to the general public, including foreign nations.

This technical report has been reviewed and is approved for publication.

*Michael G. Knoll*

MICHAEL G. KNOLL,  
1Lt, USAF  
Project Officer

*Aaron B. Loggins*

AARON B. LOGGINS,  
Lt Col, USAF  
Transient Radiation Effects Branch

FOR THE COMMANDER

*Donald A. Dowler*

DONALD A. DOWLER  
Colonel, USAF  
Chief, Electromagnetics Division

DO NOT RETURN THIS COPY. RETAIN OR DESTROY.





UNCLASSIFIED

SECURITY CLASSIFICATION OF THIS PAGE (When Data Entered)

REPORT DOCUMENTATION PAGE		READ INSTRUCTIONS BEFORE COMPLETING FORM
1. REPORT NUMBER <b>14</b> AFWL-TR-78-5	2. GOVT ACCESSION NO.	3. RECIPIENT'S CATALOG NUMBER
4. TITLE (and Subtitle) <b>6</b> COMPARISON STUDY OF THE FIVE TRANSISTOR- TRANSISTOR-LOGIC (TTL) FAMILIES AND EMITTER COUPLED LOGIC (ECL).		5. TYPE OF REPORT & PERIOD COVERED <b>9</b> Final Report.
7. AUTHOR(s) <b>10</b> Michael G. Knoll		6. PERFORMING ORG. REPORT NUMBER
9. PERFORMING ORGANIZATION NAME AND ADDRESS Air Force Weapons Laboratory Kirtland Air Force Base, New Mexico 87117		8. CONTRACT OR GRANT NUMBER(s) <b>16</b> WDNE <b>17</b> 20
11. CONTROLLING OFFICE NAME AND ADDRESS Director Defense Nuclear Agency Washington, D.C. 20305		10. PROGRAM ELEMENT, PROJECT, TASK AREA & WORK UNIT NUMBERS Program Element: 62704H JON: WDNE2001
14. MONITORING AGENCY NAME & ADDRESS (if different from Controlling Office) Air Force Weapons Laboratory Kirtland Air Force Base, New Mexico 87117		12. REPORT DATE <b>11</b> May 1978 13. NUMBER OF PAGES 100 <b>12</b> 93 p.
		15. SECURITY CLASS (of this report) UNCLASSIFIED 15a. DECLASSIFICATION/DOWNGRADING SCHEDULE
16. DISTRIBUTION STATEMENT (of this Report)  Approved for public release; distribution unlimited.		
17. DISTRIBUTION STATEMENT (of the abstract entered in Block 20, if different from Report)		
18. SUPPLEMENTARY NOTES  This research was sponsored by the Defense Nuclear Agency under Subtask Z99QXTB029, Work Unit 62, Radiation Characterization of MSI/LSI.		
19. KEY WORDS (Continue on reverse side if necessary and identify by block number) Logic Circuits                      Neutron Integrated Circuits                Total Dose Bipolar Systems                    Test Methods Radiation Tests Dose Rate		
20. ABSTRACT (Continue on reverse side if necessary and identify by block number) <b>A</b> This report describes the radiation test response of the five transistor- transistor-logic (TTL) technologies and the emitter-coupled-logic (ECL) tech- nology. The five TTL technologies evaluated were Standard, High Speed, Low Power, Low Power Schottky, and Schottky. Quad dual input NAND (TTL) or NOR (ECL) gates and dual D flip-flops from each technology were tested. The devices were characterized for gamma dose-rate logic upset, total gamma dose survivability, and neutron fluence survivability. The data has been analyzed to provide a comparison of each logic technology's radiation response.		

DD FORM 1 JAN 73 1473

EDITION OF 1 NOV 65 IS OBSOLETE

UNCLASSIFIED

SECURITY CLASSIFICATION OF THIS PAGE (When Data Entered)

013150

78 07 27 038

# CONTENTS

<u>Section</u>	<u>Page</u>
I INTRODUCTION	1
II ELECTRICAL CHARACTERIZATION TESTS	3
III TRANSIENT RADIATION TEST	4
IV TOTAL GAMMA DOSE RADIATION TESTS	18
V NEUTRON FLUENCE RADIATION TESTS	19
APPENDIX A - TTL & ECL CIRCUIT PERFORMANCE AND OPERATION	26
APPENDIX B - ELECTRICAL CHARACTERIZATION TESTS	28
APPENDIX C - PHOTORESPONSE PHOTOGRAPHS	39
APPENDIX D - NEUTRON FLUENCE TEST DATA	45

ACCESSION for	
NEWS	Write Section <input checked="" type="checkbox"/>
DOC	Buff Section <input type="checkbox"/>
UNANNOUNCED	<input type="checkbox"/>
JUSTIFICATION.....	
BY.....	
DISTRIBUTION/AVAILABILITY CODES	
Dist.	AVAIL. and/or SPECIAL
A	

## SECTION I

### INTRODUCTION

The objective of this study was to provide a comparative analysis of the radiation response of the TTL (transistor-transistor-logic) and ECL (emitter-coupled-logic) devices listed in table 1. This table is comprised of the five TTL families and two types of ECL gates. The five TTL families are Standard, High Speed, Low Power, Low Power Schottky, and Schottky. Quad dual input NAND (TTL) or NOR (ECL) gates and Dual D flip-flops from each TTL family and ECL type were characterized. The three types of radiation tests performed on these devices were gamma dose-rate logic upset, total gamma dose survivability, and neutron fluence survivability.

The experimental low power Schottky NAND gates listed in table 1 were produced under an Air Force Weapons Laboratory (AFWL) contract F29601-73-C-0048, "Bipolar MSI (Medium Scale Integration) Hardening Study." These NAND gates are dielectrically isolated, and have shallow junctioned arsenic doped emitters and diode photocurrent compensation.

The difference in performance and circuit operation of the five TTL families and the ECL gates is presented in appendix A.

Table 1  
LIST OF DEVICES TESTED

<u>Function</u>	<u>Device</u>	<u>Type</u>
TTL NAND	SN5400J	TI Standard
TTL NAND	SN54H00J	TI High Speed
TTL NAND	SN54L00J	TI Low Power
TTL NAND	SN54S00J	TI Schottky
TTL NAND	SN54LS00T	TI Low Power Schottky
TTL NAND	SN74LS00J	TI Low Power Schottky
TTL NAND	Experimental*	TI Low Power Schottky
ECL NOR	950459	Fairchild
ECL NOR	MC10102L	Motorola
TTL D Flip-Flop	SN5474J	TI Standard
TTL D Flip-Flop	SN54H74J	TI High Speed
TTL D Flip-Flop	SN54L74J	TI Low Power
TTL D Flip-Flop	SN54S74J	TI Schottky
TTL D Flip-Flop	SN54LS74J	TI Low Power Schottky
ECL D Flip-Flop	952859	Fairchild
ECL D Flip-Flop	MC10131L	Motorola

\* The devices labeled "Experimental" were produced by Texas Instruments (TI) for experimental purposes. The devices contain arsenic doped emitters and are not commercially available.



## SECTION II

### ELECTRICAL CHARACTERIZATION TESTS

The test devices were electrically characterized before they were subjected to the radiation environments. The electrical tests were performed on a Fairchild 5000 integrated circuit tester. All the NAND and NOR gates listed in table 1 were subjected to approximately the same electrical tests. Likewise, all the D flip-flops were subjected to similar electrical tests. The electrical tests performed on the devices were output voltage, power supply current, input current, propagation delay times, and short circuit output current (not performed on ECL devices). The output high and output low voltages were measured on the TTL devices with the following source and sink currents applied:

<u>Device Type</u>	<u>Source Current</u>	<u>Sink Current</u>
Standard	400 $\mu$ A	16 mA
High Speed	1 mA	20 mA
Schottky	1 mA	20 mA
Low Power	100 $\mu$ A	2 mA
Low Power Schottky	400 $\mu$ A	4 mA

These sink and source currents represent a fanout of ten. The electrical tests were performed on the ECL devices with each output loaded with a 50-ohm resistor connected to a minus-two-volt power supply.

Appendix B contains a detailed description of the electrical characterization tests performed on the TTL and ECL devices.

### SECTION III

#### TRANSIENT RADIATION TESTS

##### 1. TEST PROCEDURES

Figure 1 shows the schematic of the general test setup used for the transient radiation logic upset tests. The TTL load is used to simulate an approximate fanout of ten. The values of  $R_L$  for the different TTL families are:

Standard, High Speed, and Schottky -  $R_L = 200\Omega$

Low Power and Low Power Schottky -  $R_L = 800\Omega$

A 0.1  $\mu$ F capacitor is applied in parallel with the power supplies to hold them constant during the radiation pulse. Fifty-ohm terminators were used at the oscilloscopes to reduce reflections down the coaxial cables.

The LH0033C unity gain line drivers were used with a divide-by-two resistive divider to provide the necessary drive for the 50-ohm terminated coaxial cables. The NAND and NOR gates were irradiated with both inputs DC biased either at their input high voltage or their input low voltage to get the necessary output low and high voltages, respectively. The D flip-flops were biased dynamically during the radiation pulse as illustrated in figure 2.

The transient radiation tests were performed at the AFWL Flash X-ray facility. The pulse width produced by this FXR is approximately 20 nanoseconds. The output voltage of the devices was monitored during the radiation pulse. Logic upset threshold for the TTL NAND gates is defined as 0.8 volt for the output low voltage and 2.0 volts for the output high



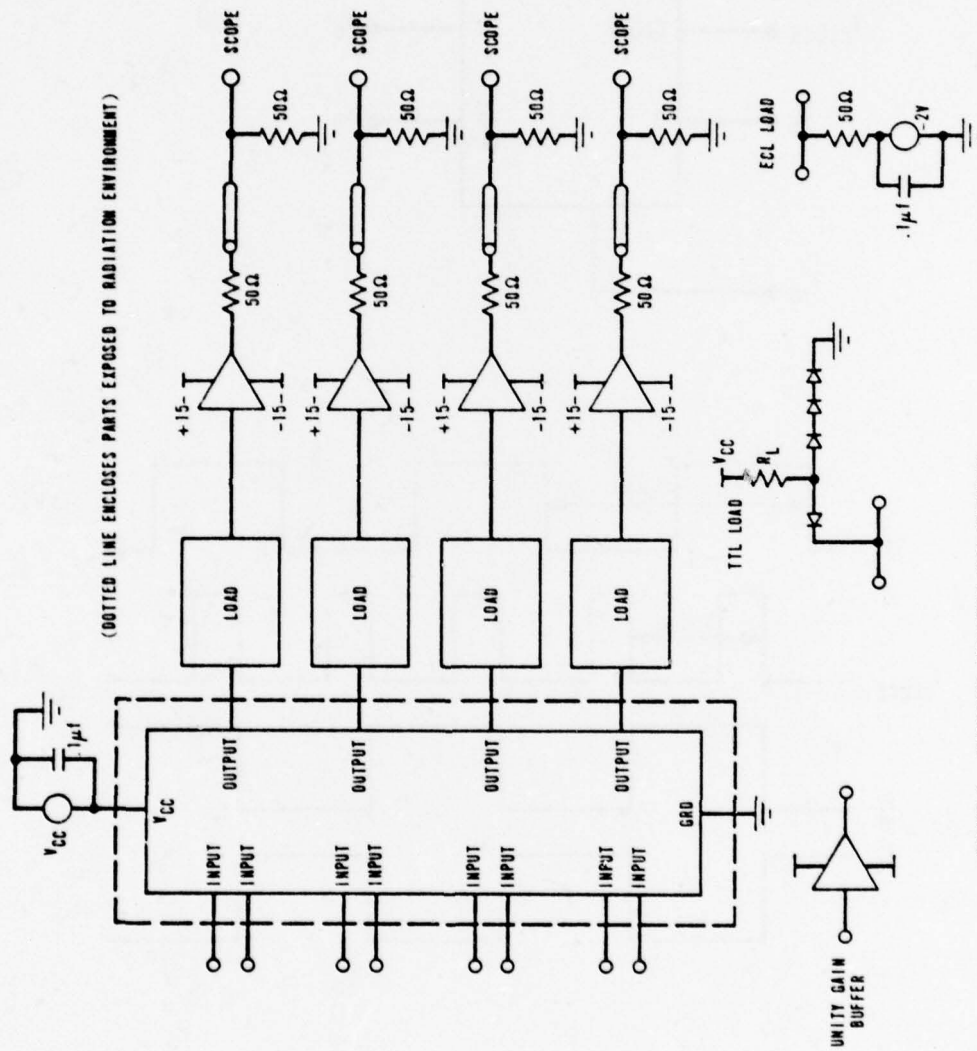


FIGURE 1. TRANSIENT RADIATION TEST SCHEMATIC

Figure 1. Transient Radiation Test Schematic.

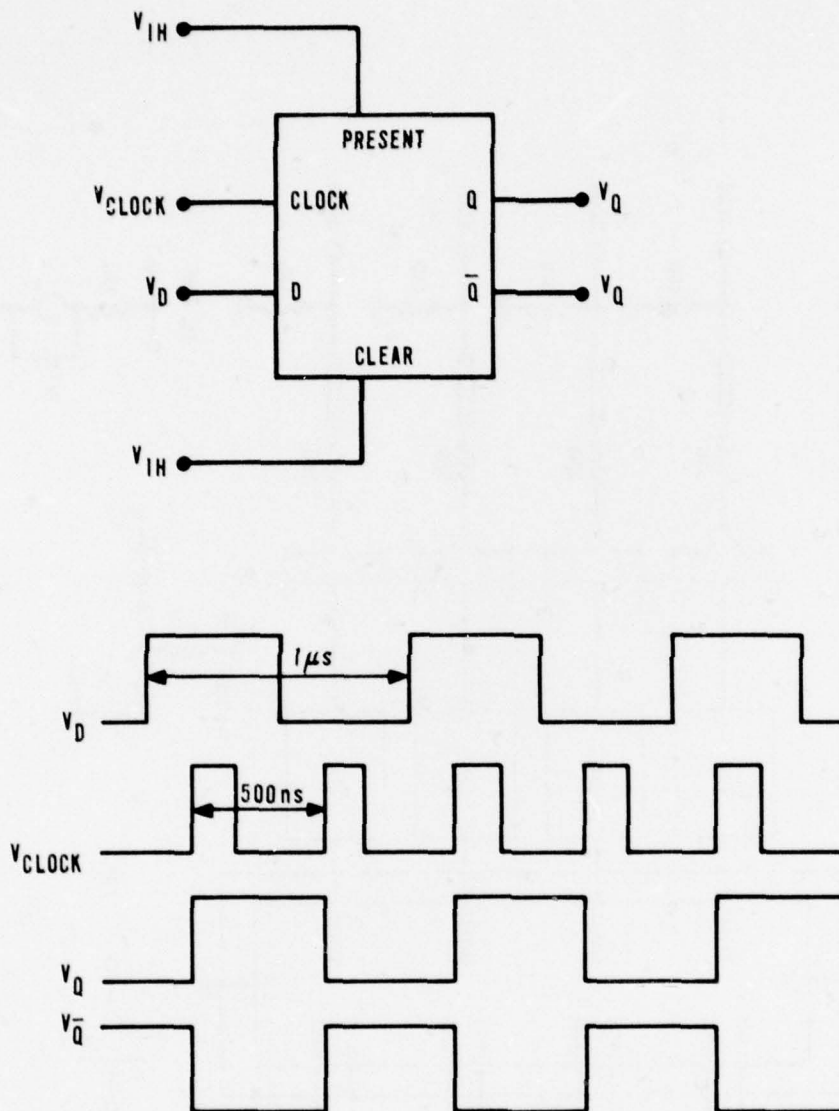


FIGURE 2. D FLIP-FLOP BIAS CONDITIONS DURING THE TRANSIENT RADIATION TESTS

Figure 2. D Flip-Flop Bias Conditions During the Transient Radiation Tests

voltage. For the ECL NOR gates the logic upset threshold is defined as - 1.100 volts and - 1.500 volts for output high and output low voltages, respectively. The D flip-flops logic upset threshold occurs when the radiation pulse causes the flip-flop to change state. Three devices of each device type were tested. The devices were tested at the following transient dose rates:

NAND and NOR Gates

$1.8 \times 10^8 \text{ rad(Si)/s}$

$3.6 \times 10^8 \text{ rad(Si)/s}$

$7.2 \times 10^8 \text{ rad(Si)/s}$

$1.4 \times 10^9 \text{ rad(Si)/s}$

$3.2 \times 10^9 \text{ rad(Si)/s}$

$6 \times 10^9 \text{ rad(Si)/s}$

D Flip-Flops

$2 \times 10^8 \text{ rad(Si)/s}$

$4.4 \times 10^8 \text{ rad(Si)/s}$

$7 \times 10^8 \text{ rad(Si)/s}$

## 2. TEST RESULTS

All three devices of each particular type exhibited approximately the same transient radiation response. The largest tested transient dose-rates at which all the tested devices operated without logic upset are shown below:

Device Type

Dose-Rate

SN5400J

$7.2 \times 10^8 \text{ rad(Si)/s}$

SN54H00J

$7.2 \times 10^8 \text{ rad(Si)/s}$

SN54S00J

$7.2 \times 10^8 \text{ rad(Si)/s}$

SN54L00J

$3.6 \times 10^8 \text{ rad(Si)/s}$

SN54LS00T

$3.6 \times 10^8 \text{ rad(Si)/s}$

Experimental

$3.2 \times 10^9 \text{ rad(Si)/s}$

<u>Device Type</u>	<u>Dose-Rate</u>
950459	$3.6 \times 10^8 \text{ rad(Si)/s}$
MC10102L	$3.6 \times 10^8 \text{ rad(Si)/s}$
SN5474J	$4.4 \times 10^8 \text{ rad(Si)/s}$
SN54H74J	$4.4 \times 10^8 \text{ rad(Si)/s}$
SN54S74J	$4.4 \times 10^8 \text{ rad(Si)/s}$
SN54L74J	$2 \times 10^8 \text{ rad(Si)/s}$
SN54LS74J	$2 \times 10^8 \text{ rad(Si)/s}$
952859	$4.4 \times 10^8 \text{ rad(Si)/s}$
MC10131L	$4.4 \times 10^8 \text{ rad(Si)/s}$

Graphs illustrating the complete photoresponse of the TTL NAND and ECL NOR gates are shown in figures 3 through 10.

Appendix C contains oscilloscope photographs showing the radiation response of some of the devices tested.

The Standard, High Speed, and Schottky TTL devices are more resistant to the transient ionizing radiation than the Low Power and Low Poser Schottky TTL devices. The higher current densities of the Standard, High Speed, and Schottky TTL devices will sweep out the hole-electron pairs generated during the transient radiation pulse more efficiently than the lower current densities of the Low Power TTL devices. Similarly, since ECL operates at high current densities, the ECL D flip-flops exhibit the same failure threshold as the Standard, High Speed, and Schottky TTL D flip-flops. However, the ECL NOR gates exhibited a lower failure threshold than the Standard, High Speed, and Schottky TTL NAND gates. This discrepancy



may be due to the failure thresholds being defined too conservatively. The experimental arsenic doped emitter TTL NAND gates produced by Texas Instruments were an order of magnitude harder to the transient ionizing radiation than the equivalent Low Power Schottky devices (SN54LS00T). These experimental gates are dielectrically isolated and have extremely small geometries and diode photocurrent compensation. These factors result in the increased dose-rate hardness.

The NAND gates are harder than the D flip-flops of the same TTL technology. The D flip-flop is softer to the radiation pulse because after the clock pulse, the D flip-flop is a memory device (see figure 2). Therefore, the D flip-flop will be more susceptible to a perturbation caused by the transient radiation pulse than the NAND gate, whose output is directly dependent on the input during the pulse.

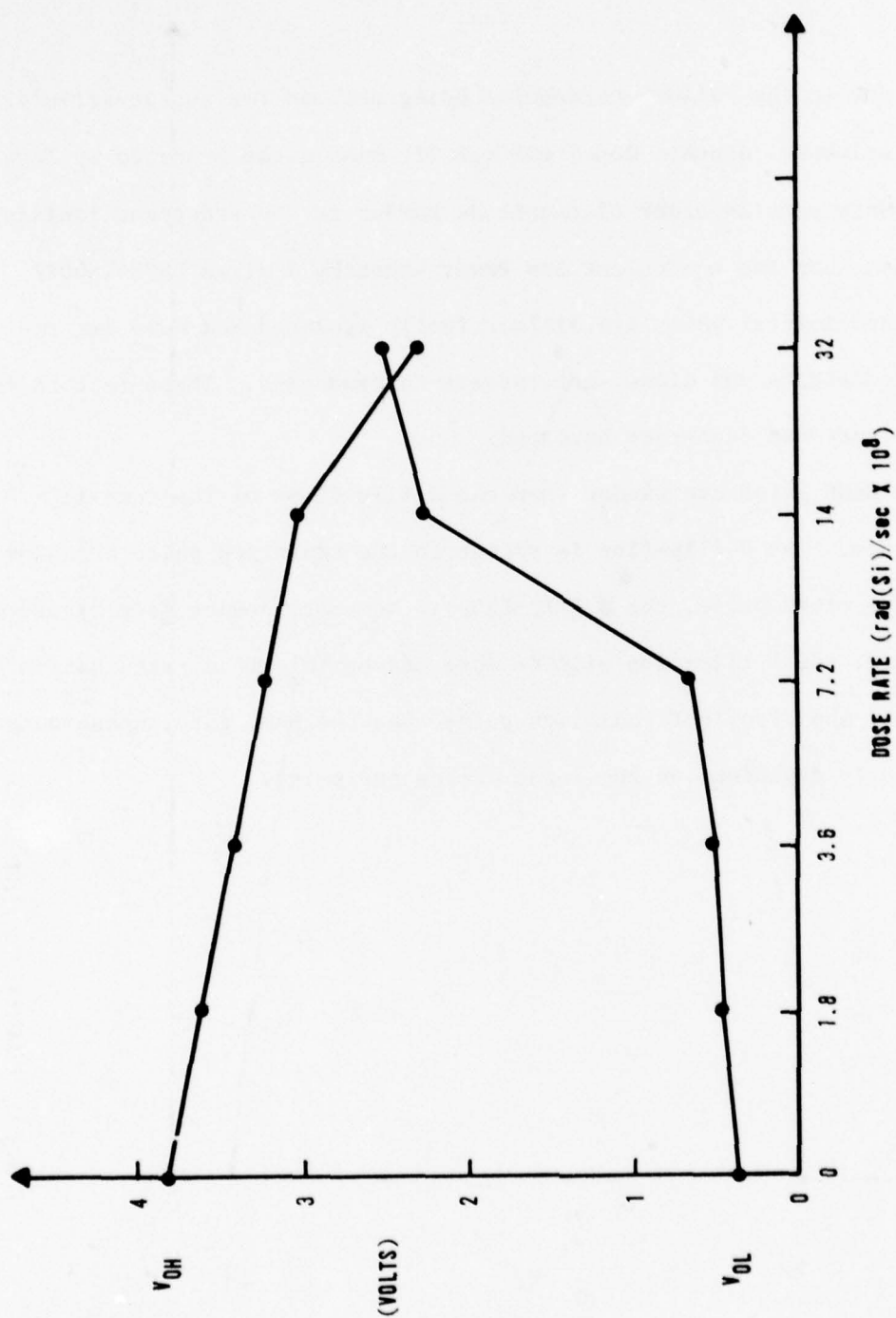


Figure 3. Transient Radiation Response of TTL SN5400J NAND Gate



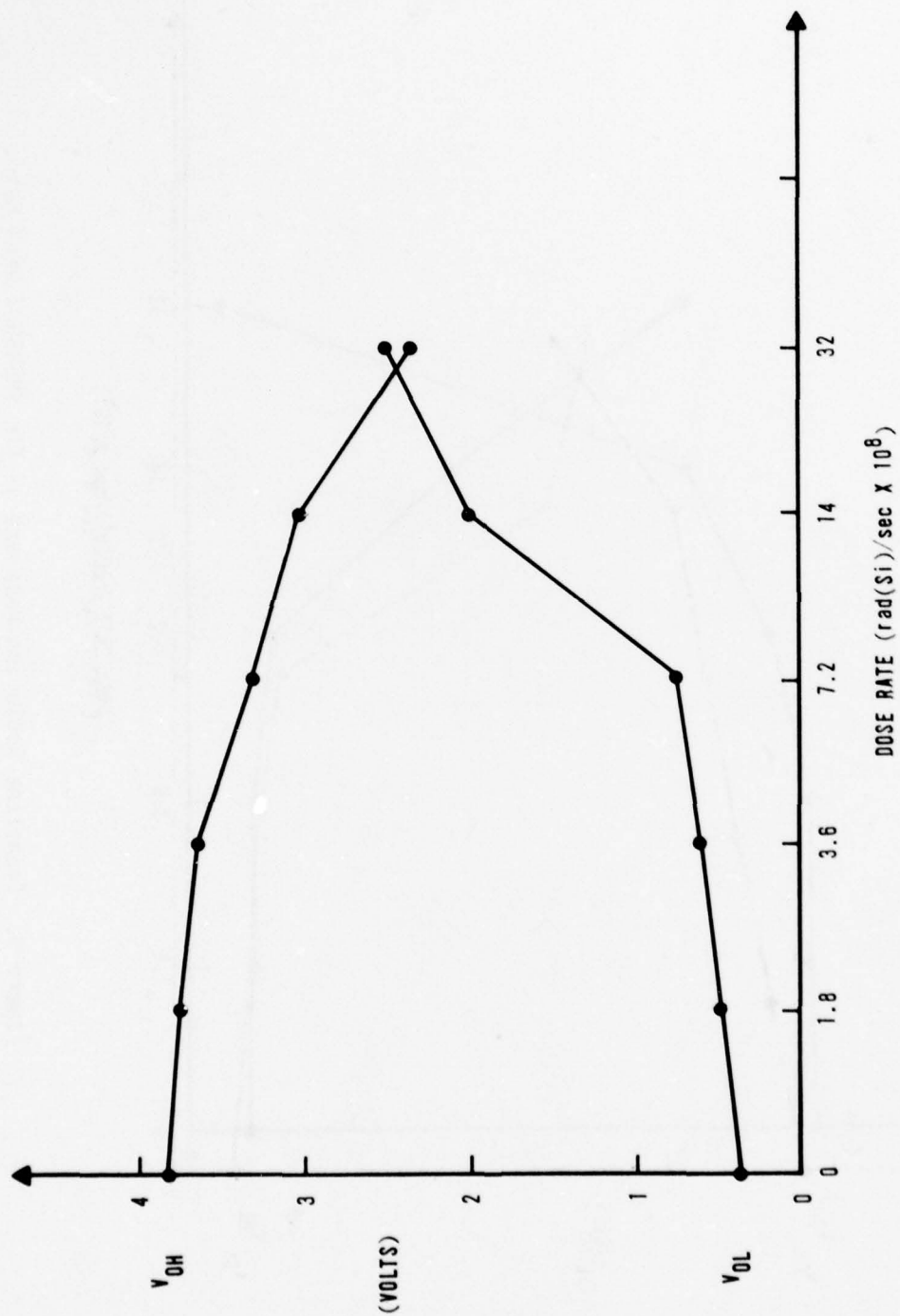


FIGURE 4. TRANSIENT RADIATION RESPONSE OF TTL SN54H00J NAND GATE

Figure 4. Transient Radiation Response of TTL SN54H00J NAND Gate.

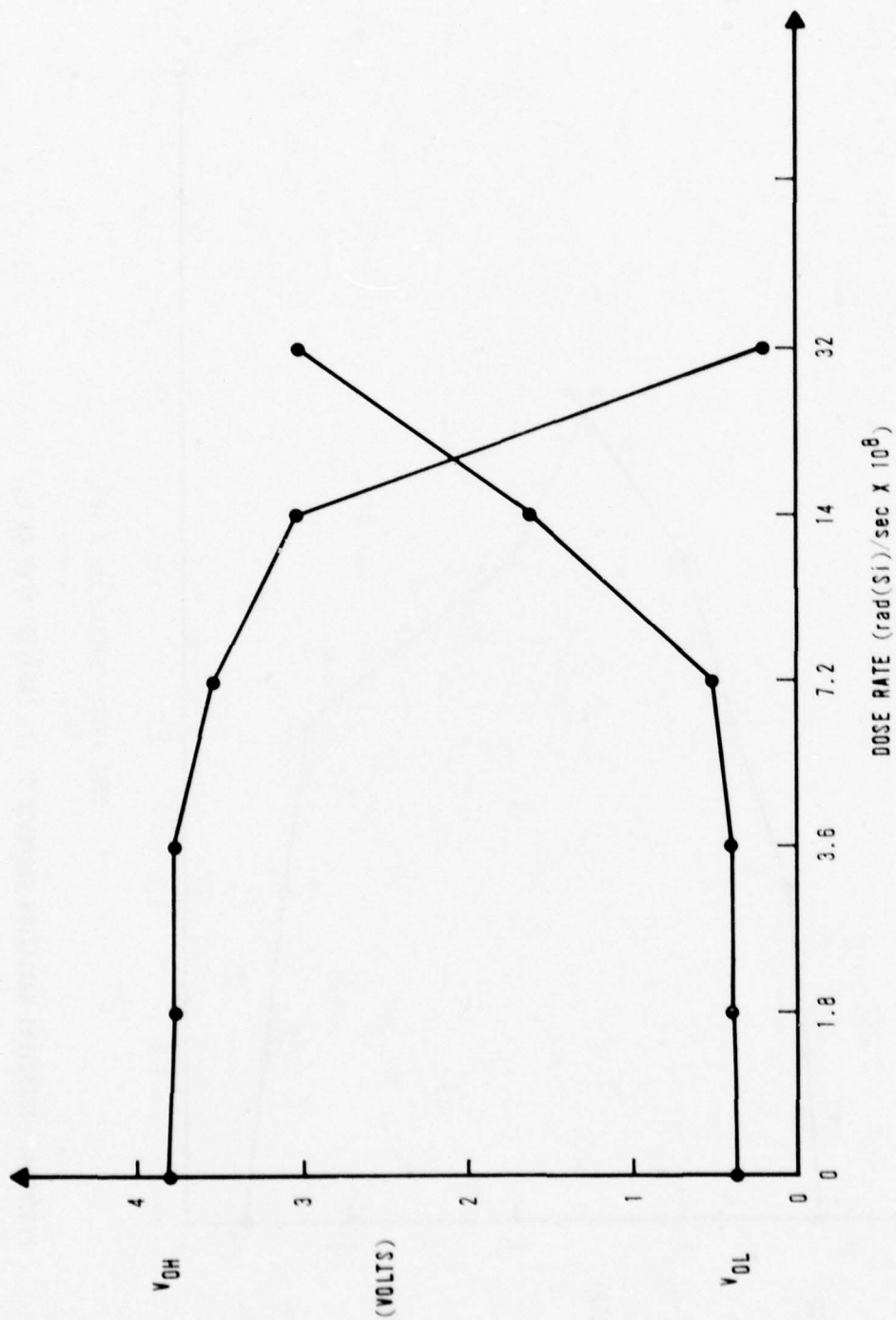


Figure 5. Transient Radiation Response of TTL SN54S00J NAND Gate.

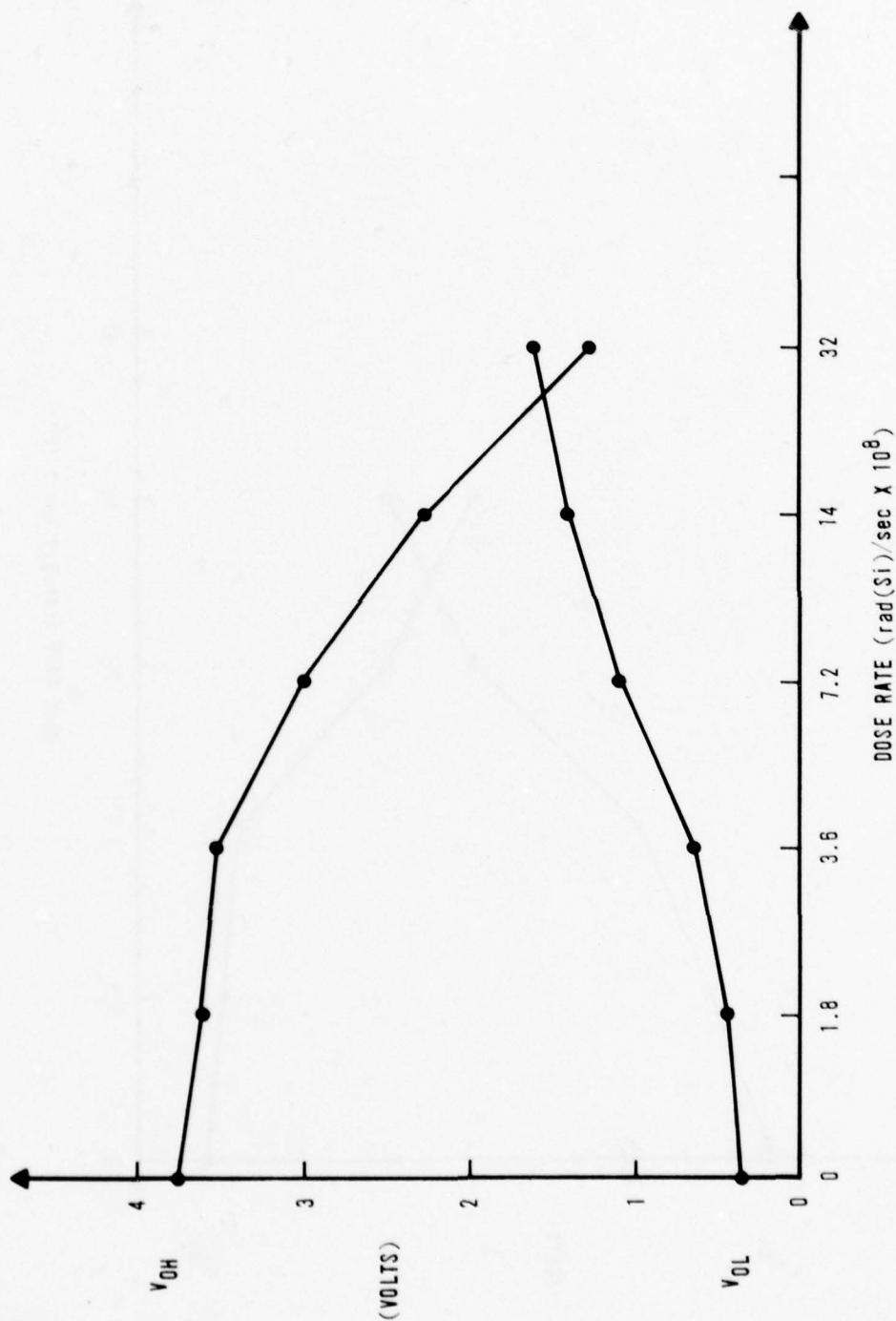


Figure 6. Transient Radiation Response of TTL Sn54L00J Nand Gate

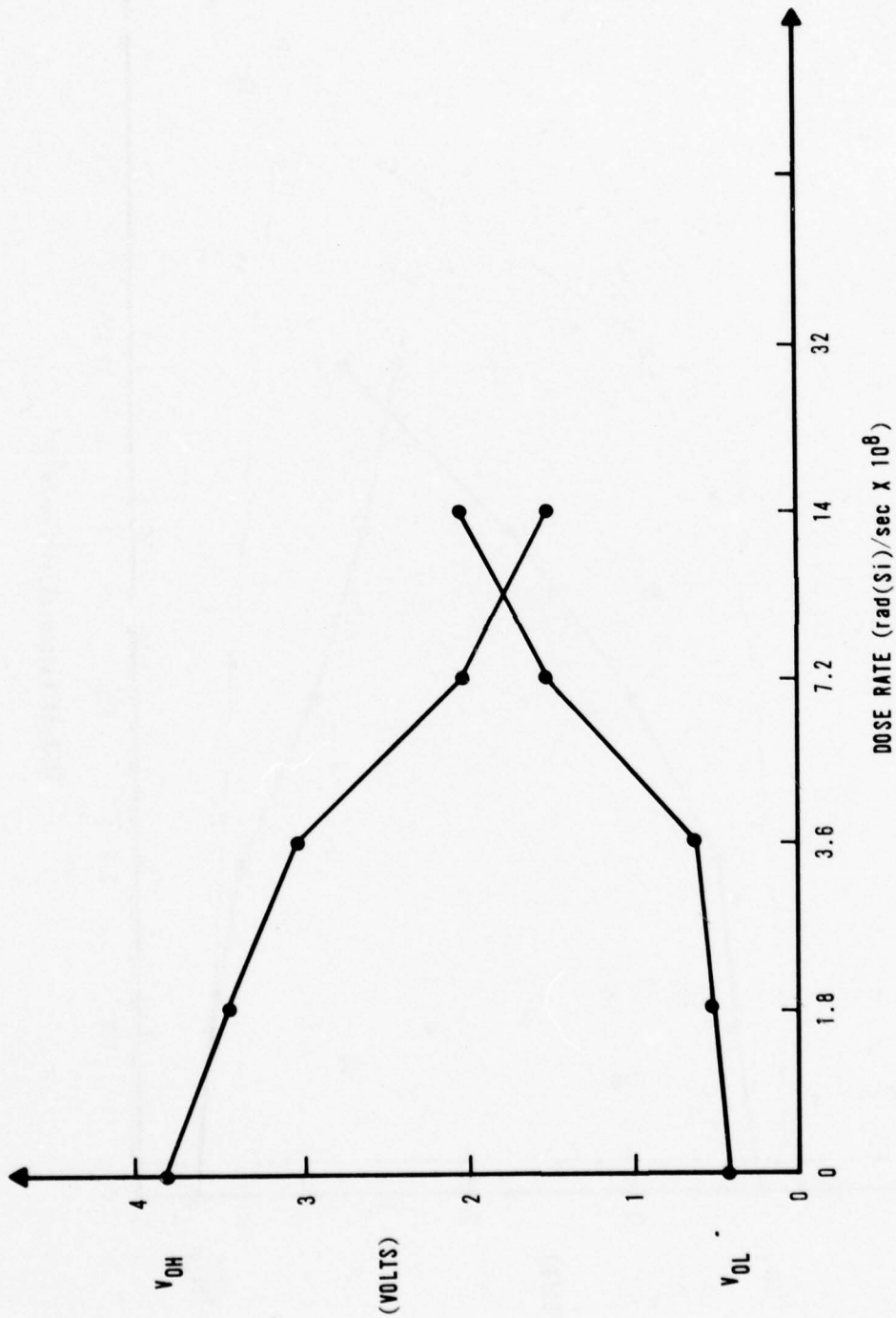


Figure 7. Transient Radiation Response of TTL SN54LS00J Nand Gate.

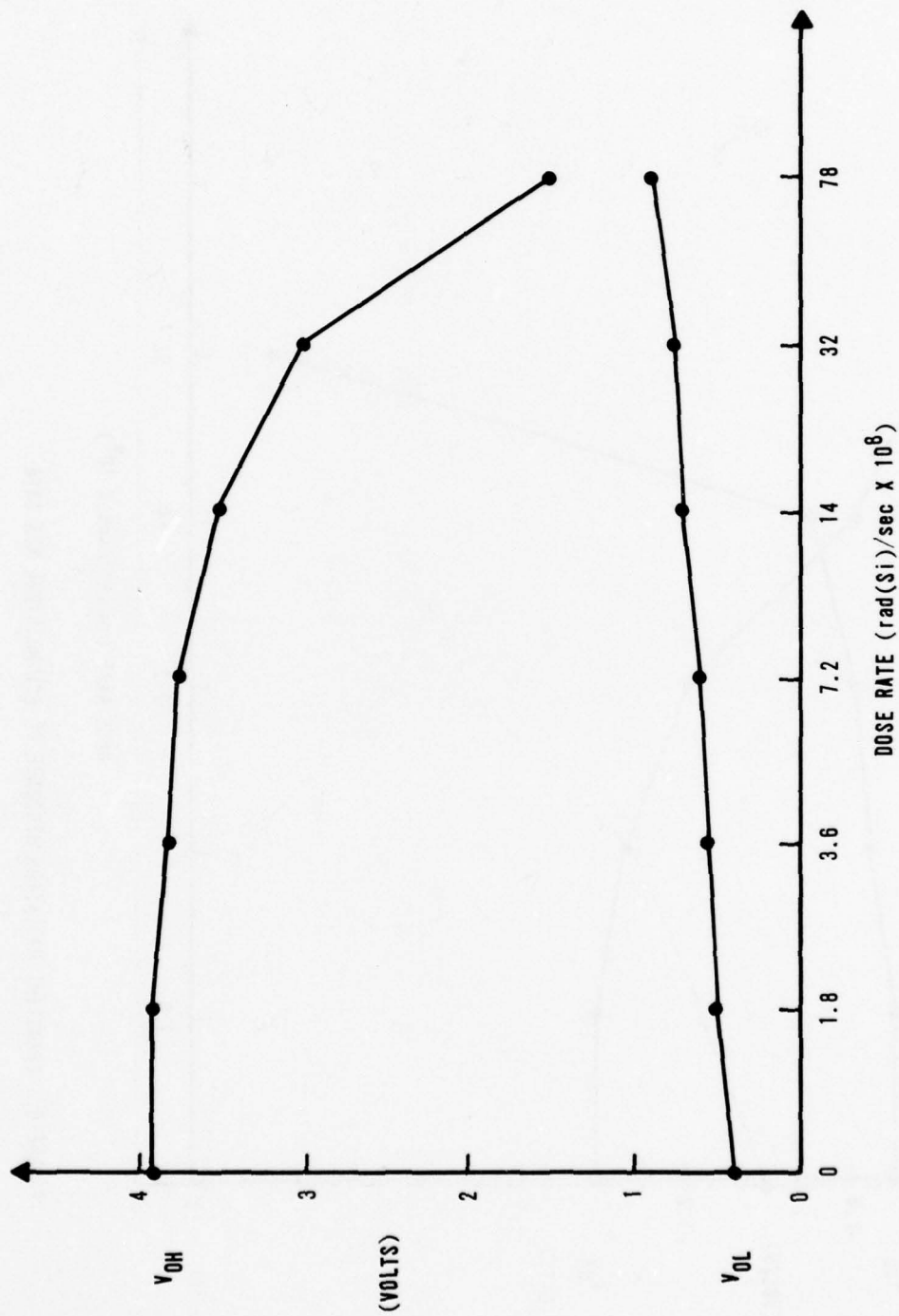


Figure 8. Transient Radiation Response of TTL Experimental 1 Nand Gate.



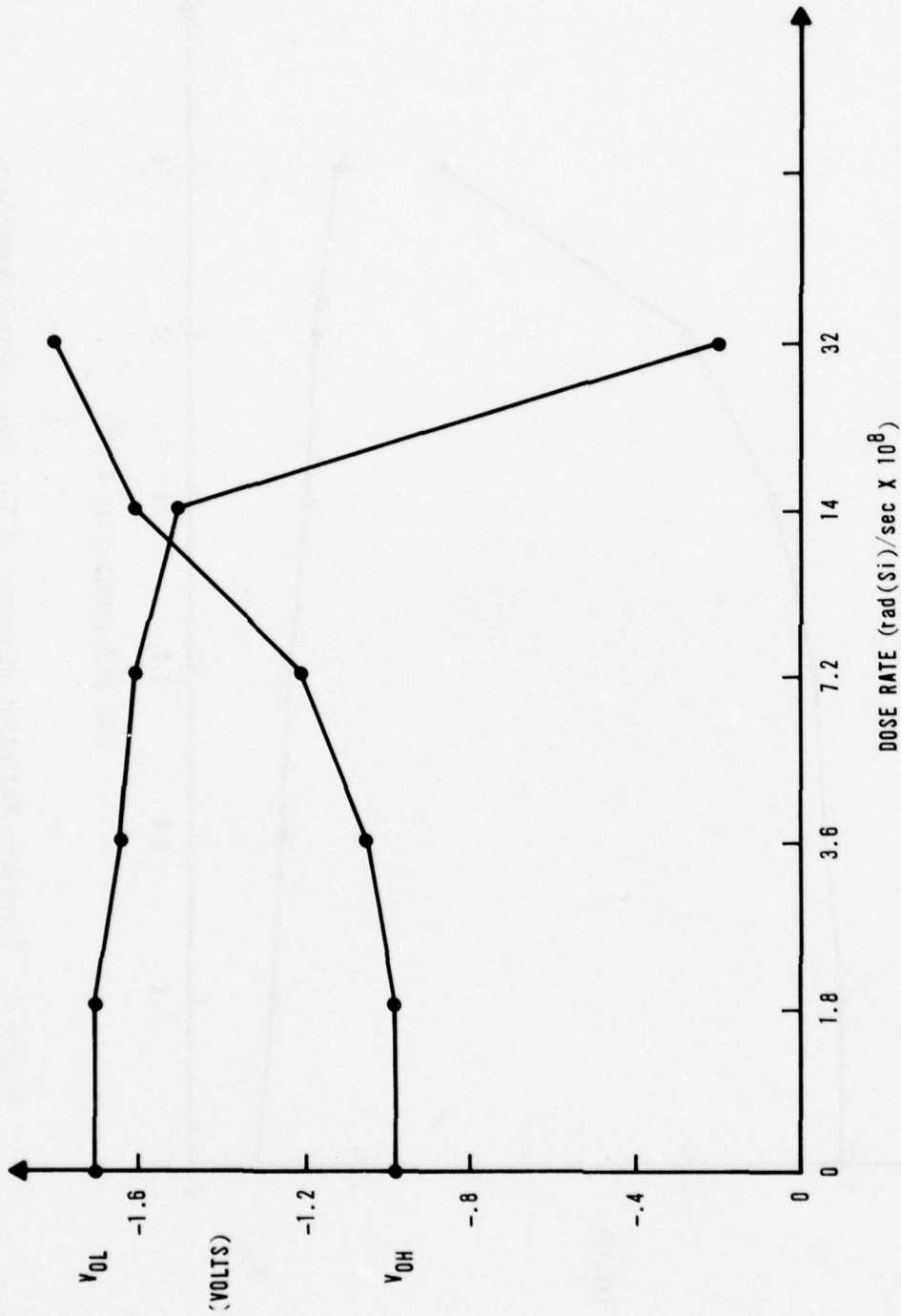


FIGURE 9. TRANSIENT RADIATION RESPONSE OF ECL MC10102L NOR GATE

Figure 9. Transient Radiation Response of ECL MC10102L NOR Gate.



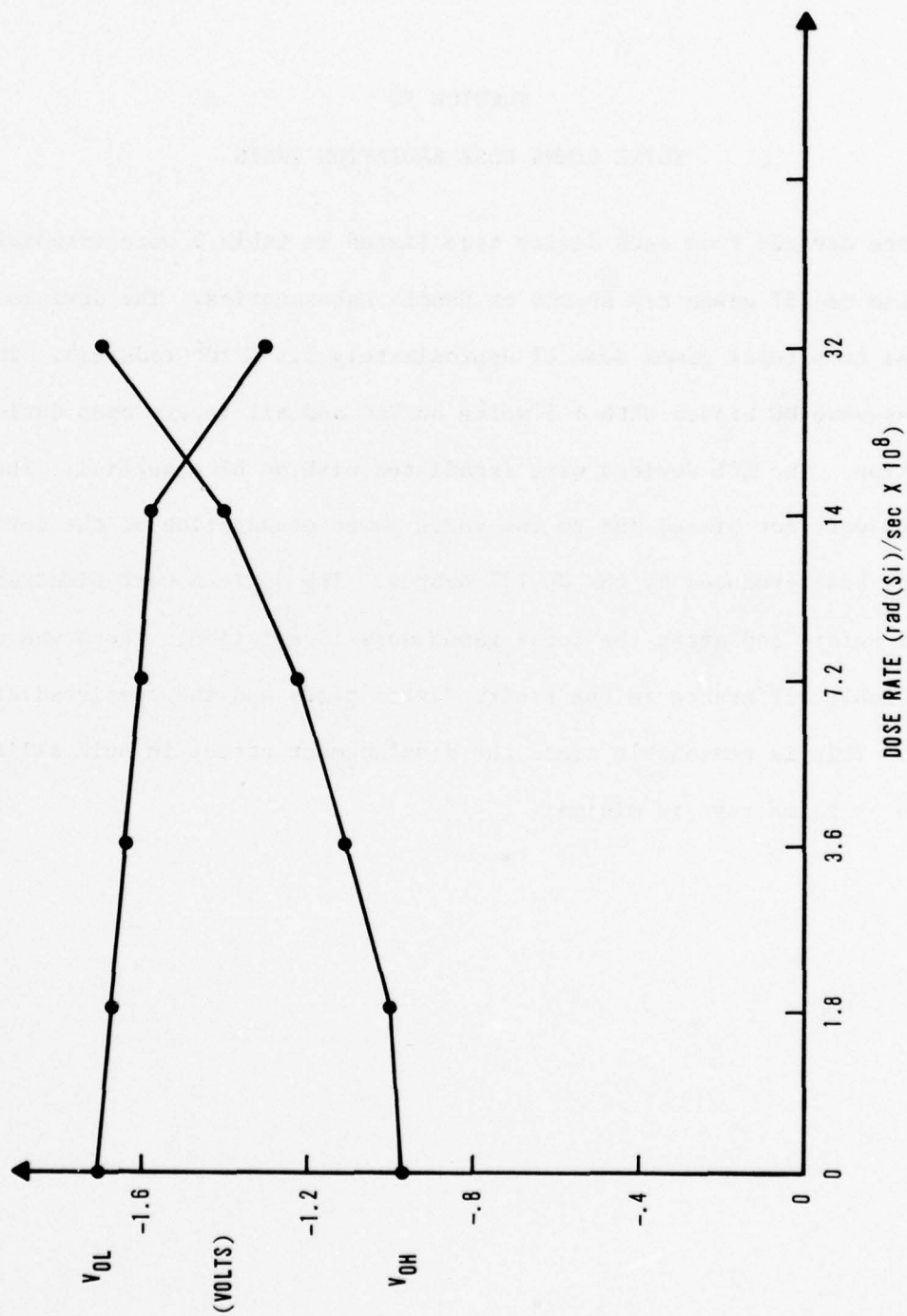


Figure 10. Transient Radiation Response of ECL 950459 NOR Gate.

#### SECTION IV

##### TOTAL GAMMA DOSE RADIATION TESTS

Three devices from each device type listed in table 1 were irradiated with the Cs-137 gamma ray source at Sandia Laboratories. The devices were exposed to a total gamma dose of approximately  $1.5 \times 10^6$  rads(Si). The TTL devices were DC biased with + 5 volts on VCC and all inputs open during the radiation. The ECL devices were irradiated with no bias applied. The ECL devices were not biased due to the large power consumption of the devices and the heat produced by the Cs-137 source. The devices were electrically tested before and after the total gamma dose irradiation. There was no appreciable difference in the preirradiated tests and the postirradiated tests. This is reasonable since the displacement effect in bulk silicon caused by gamma rays is minimal.

## SECTION V

### NEUTRON FLUENCE RADIATION TESTS

#### 1. TEST PROCEDURES

Three or four devices from each device type listed in table 1 were irradiated with the fast burst reactor at Sandia Laboratories in incremental neutron fluence levels. After each incremental radiation dose was reached, the devices were electrically tested. The cumulative neutron fluence levels at which the devices were electrically tested were approximately  $2.8 \times 10^{12}$  n/cm<sup>2</sup>,  $6.9 \times 10^{13}$  n/cm<sup>2</sup>,  $1.4 \times 10^{14}$  n/cm<sup>2</sup>,  $7.3 \times 10^{14}$  n/cm<sup>2</sup>,  $1.2 \times 10^{15}$  n/cm<sup>2</sup>, and  $2 \times 10^{15}$  n/cm<sup>2</sup>. These fluence levels are 1 MeV equivalent. Approximately 80 devices were irradiated simultaneously with no electrical bias applied to them. Output voltage failure thresholds for these tests are the same as defined for the transient radiation tests.

#### 2. TEST RESULTS

Appendix D contains the neutron fluence test data that were gathered on the devices listed in table 1. These data are presented in the form of tables. Upon examination of these data, it is apparent that the neutron fluence survivability threshold for a particular device type is approximately the same for the NAND or NOR gates as for the D flip-flops of the same type. The largest tested neutron fluences at which all the tested devices will operate before the output voltage failure threshold occurs are shown below:

Standard TTL (SN5400J and SN5474J)	= $1.4 \times 10^{14}$ n/cm <sup>2</sup>
High Speed TTL (SN54H00J and SN54H74J)	= $4.6 \times 10^{14}$ n/cm <sup>2</sup>

Schottky TTL (SN54S00J and SN54S74J)	= $1.2 \times 10^{15}$ n/cm <sup>2</sup>
Low Power TTL (SN54L00J and SN54L74J)	= $1.4 \times 10^{14}$ n/cm <sup>2</sup>
Low Power Schottky TTL (SN54LS00T and SN54L574J)	= $1.4 \times 10^{14}$ n/cm <sup>2</sup>
Experimental TTL	= $7.3 \times 10^{14}$ n/cm <sup>2</sup>
Fairchild ECL (950459 and 952859)	= $4.6 \times 10^{14}$ n/cm <sup>2</sup>
Motorola ECL (MC10102L and MC10131L)	= $4.6 \times 10^{14}$ n/cm <sup>2</sup>

All the TTL devices failed when the output low voltage became larger than the failure threshold. Figure 11 provides graphs of the averaged output voltage of the different TTL families versus neutron fluence. The Fairchild 5000 was not allowed to measure greater than 1.638 volts for the output low voltage for the TTL devices. As can be seen from this figure, the degradation of the output voltage is very gradual until the device fails. At the point of failure, the output low voltages rise suddenly. These output low voltage failures in the TTL devices are a result of the neutron-caused beta degradation of Q1 shown in figure 12. When beta is decreased sufficiently by the neutron radiation, the sink current being forced at the output will cause transistor Q1 to come out of saturation and enter the linear region of operation. As a result of the transistor entering the linear region, the collector-emitter voltage ( $V_{CE}$ ), which equals the output low voltage, increases to failure. Since the sink current simulates a fanout of ten, the output low voltage failure thresholds are correct for this worst case condition. However, if the NAND gates were

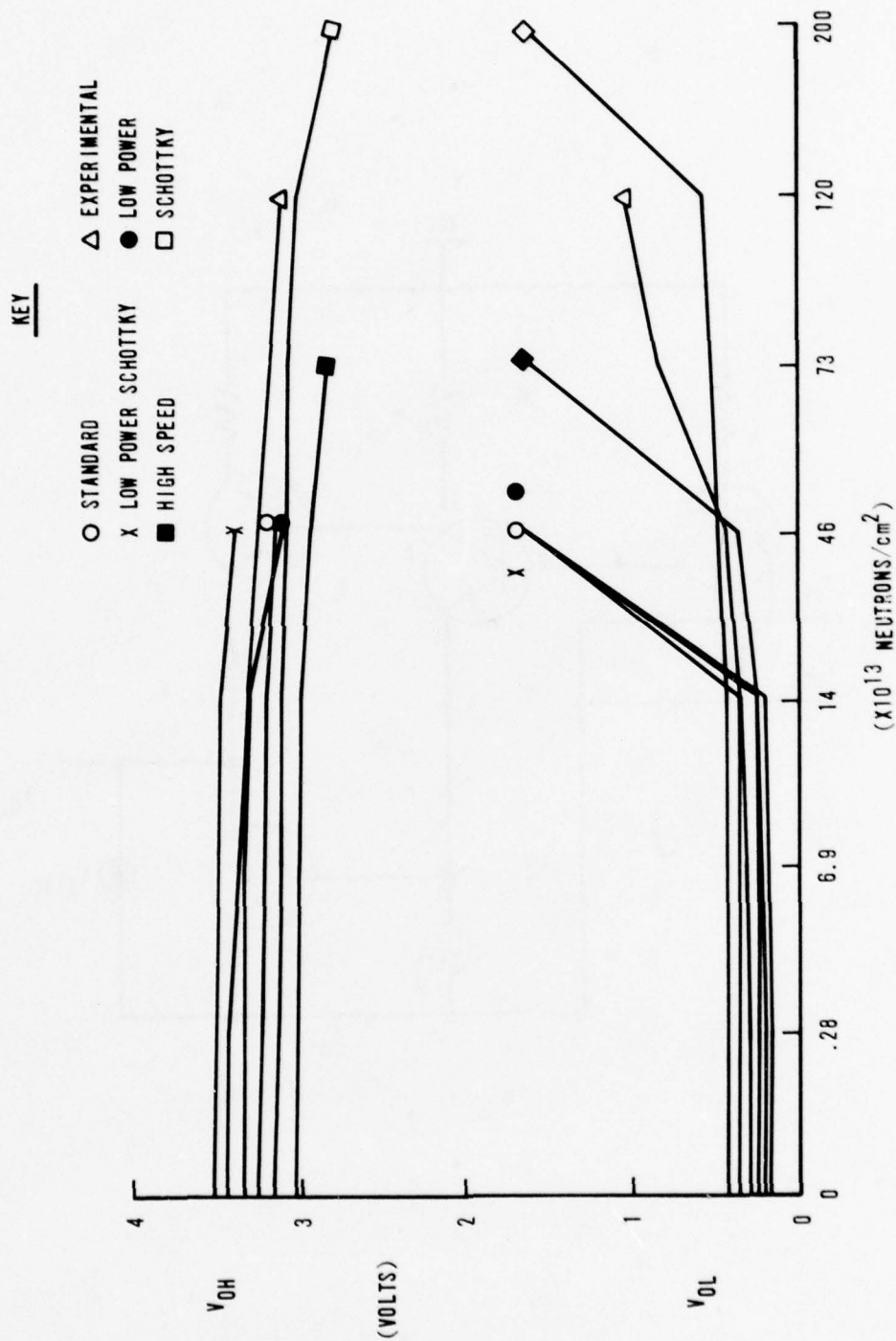


Figure 11. TTL Output Voltage Versus Neutron Fluence.



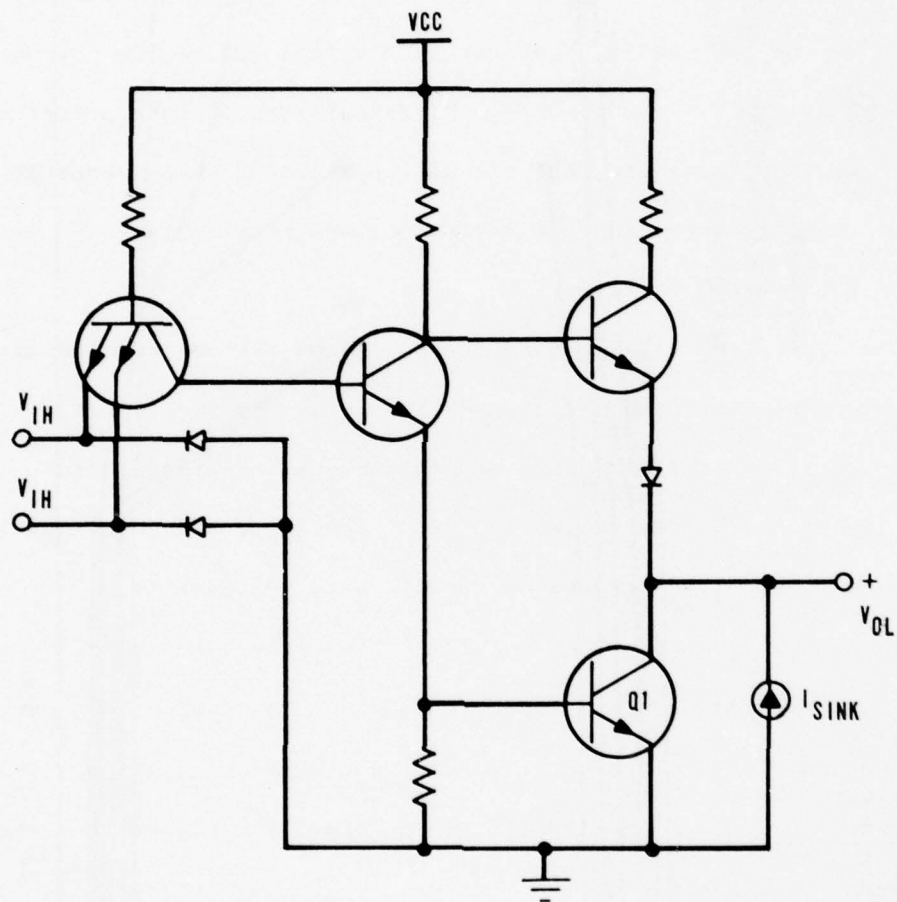


Figure 12. Schematic of a Typical 5400 Series Nand Gate.



tested with a smaller sink current, which is equivalent to a smaller fanout, the output low voltage would not have failed until a higher neutron fluence level. This conclusion cannot directly apply to the TTL flip-flops because one of the internal gates, which does not have the same circuit design as the 5400 series NAND gates, may fail before the output NAND gates of the flip-flop. In ECL gates, the transistors operate primarily in the linear region; therefore, the circuit operation is more sensitive to degradations in beta, and the neutron-caused beta degradation ultimately causes the voltage failures.

The other electrical parameters tested on the devices (power supply current, input current, and propagation delay times) did not deviate appreciably from their maximum or minimum specifications before the output voltage changes caused failure. The input and power supply currents generally decreased due to the beta degradation.

As shown above, the High Speed TTL, Schottky TTL, and ECL gates operated at larger neutron fluences than the lower power TTL devices. The neutron-caused displacement damage in these devices results in decreased recombination lifetime in the base. If the emitter areas and the base transit times of the transistors of the different TTL families are assumed approximately equal, then the recombination rate/carrier is less for devices which operate at higher currents (ref. 1). This explains why the higher-power devices are more resistant to neutron radiation.

- 
1. Larin, Frank, Radiation Effects in Semiconductor Devices, New York, NY, John Wiley and Sons, Inc., 1968, pp 159-169.

The Texas Instruments Experimental arsenic doped emitter TTL gates were much harder to the neutron radiation than the equivalent Low Power Schottky devices (SN54LS00T). The very sharp arsenic doped emitter profile in these devices is primarily responsible for the increased neutron hardness. The resulting abrupt emitter-base region width decreases the amount of emitter-base depletion region recombination, resulting in increased neutron hardness (ref. 2).

- 
2. Gwyn, G.W., and Gregory, B.L., "Designing Ultrahard Bipolar Transistors", Sandia Laboratories Technical Report, September 1971.

## SECTION VI

### CONCLUSIONS

This report shows that, of the commercially available TTL devices, the High Speed and Schottky devices are the hardest to all the radiation environments. However, as shown by the Experimental NAND gate data, the Low Power Schottky devices can be made very hard with dielectric isolation, small geometries, and arsenic doped emitters. The ECL devices were not harder than the higher-power TTL devices, even though their power consumption is much higher. This is probably due to the linear operation and small noise margin of ECL. As expected, the NAND gates were more resistant to the transient radiation pulse than the D flip-flops, since the flip-flops are memory devices. A variation in the electrical testing of the output voltage would have been beneficial. The output voltage of the devices could have been tested for various fanout sink currents instead of just for a fanout of ten. This would have provided more information to the designer on neutron survivability of the gates for less than worst case conditions.

## APPENDIX A

## TTL AND ECL CIRCUIT PERFORMANCE AND OPERATION

The Five TTL families and ECL gates can be classified as either saturating or nonsaturating logic. The Standard, Low Power and High Speed TTL circuit families belong in the saturating logic category. The TTL Schottky, TTL Low Power Schottky and ECL circuit families belong in the nonsaturating logic category. Nonsaturating logic differs from saturated logic in that the gates in the latter category contain transistors which saturate during circuit operation. As a result, excess charge is stored in the base of the saturated transistor resulting in slower response and propagation delay time.

The Low-Power TTL gate uses less power than the Standard TTL gate, which is shown in figure 12 of the text. This lower power results in slower propagation delay times as compared to the standard TTL technology. Similarly, the High Speed TTL devices use more power than the Standard TTL devices to gain the increased speed. The power consumption and speed are primarily controlled by the resistors in these gates.

The Schottky (S) and Low Power Schottky (LS) TTL technologies are similar to the Low Power and High Speed TTL technologies, respectively. However, the S and LS TTL technology gates contain Schottky clamped transistors to prevent them from entering the saturation region of operation. This results in decreased propagation delay time for a given current due to the absence of base excess charge caused by saturation. The Schottky clamped transistors operate at the edge of saturation when they're in a given state.

The ECL devices are capable of much faster speeds than the TTL technologies. The ECL gates are designed for a small output voltage swing, high power consumption, and linear transistor operation to attain increased speeds over other technologies.

Table A-1 of this appendix illustrates the power speed relationships of these TTL and ECL families.



Table 1. TTL AND ECL POWER SPEED RELATIONSHIPS

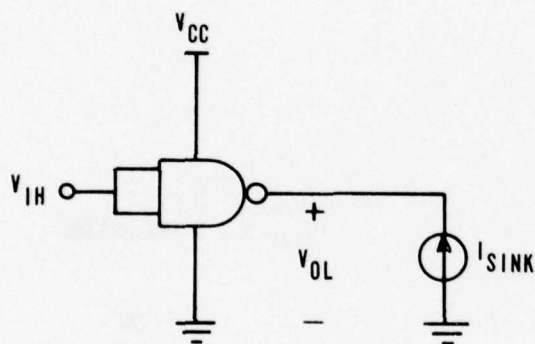
<u>Technology</u>	<u>Typical <math>P_D</math> Gate</u>	<u>Typical <math>t_p</math> Gate</u>
Standard TTL	10 mW	10 ns
Low Power TTL	1 mW	33 ns
High Speed TTL	22 mW	6 ns
Low Power Schottky TTL	2 mW	9.5 ns
Schottky TTL	19 mW	3 ns
ECL (Fairchild 95K series)	25 mW	2 ns



## APPENDIX B

### ELECTRICAL CHARACTERIZATION TESTS

This appendix contains a detailed description of the electrical characterization tests performed on the TTL and ECL devices listed in table 1 of the text. These tests were performed at the Air Force Weapons Laboratory on the Fairchild 5000/5800 Integrated Circuit Tester. Figures B1 through B12 contain the tests performed on the TTL NAND gates and D flip-flops. Figures B13 through B19 contain the tests performed on the ECL NOR gates and D flip-flops.



<u><math>I_{SINK}</math></u>	<u>TTL TYPE</u>
16 mA	STANDARD
20 mA	HIGH SPEED
20 mA	SCHOTTKY
2 mA	LOW POWER
4 mA	LOW POWER SCHOTTKY

$V_{CC} = 5V$   
 $V_{IH} = 2V$

Figure 31. TTL Output Low Voltage ( $V_{OL}$ )

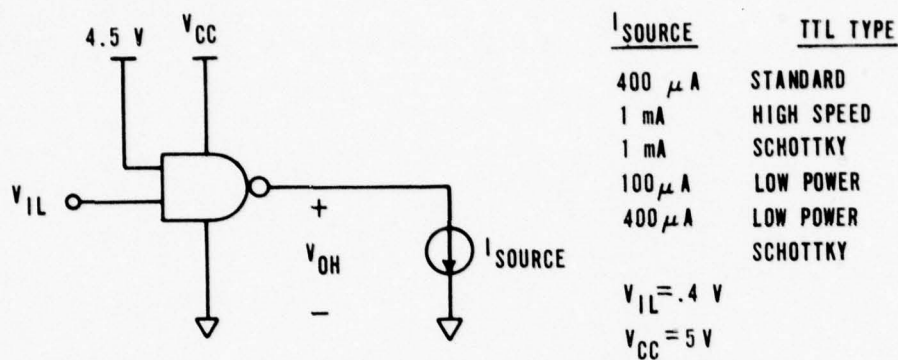


Figure B2. TTL Output High Voltage ( $V_{OH}$ )

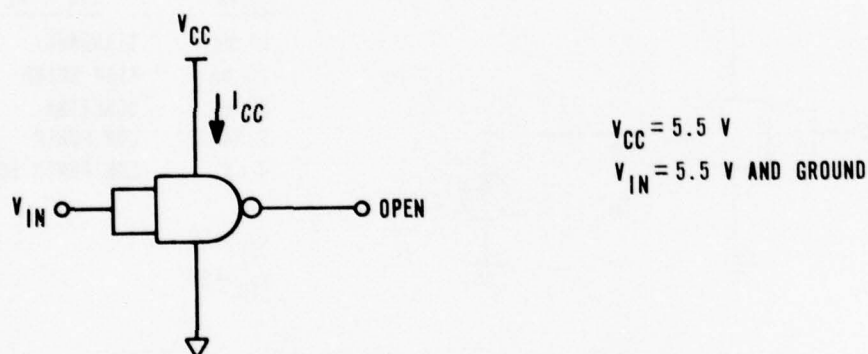


Figure B3. TTL Power Supply Current ( $I_{CC}$ )

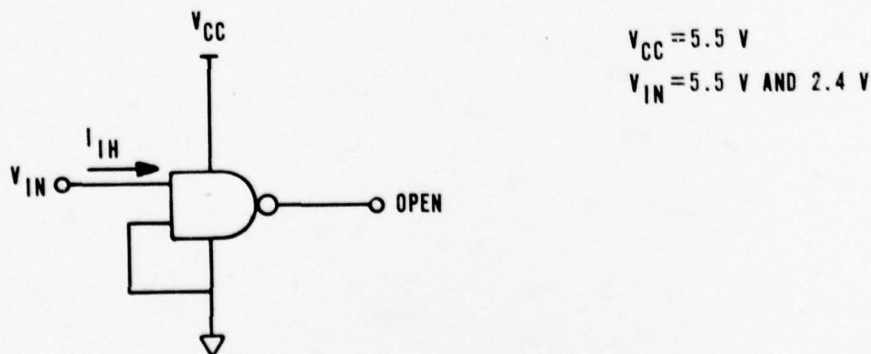


Figure B4. TTL Input High Current ( $I_{IH}$ )

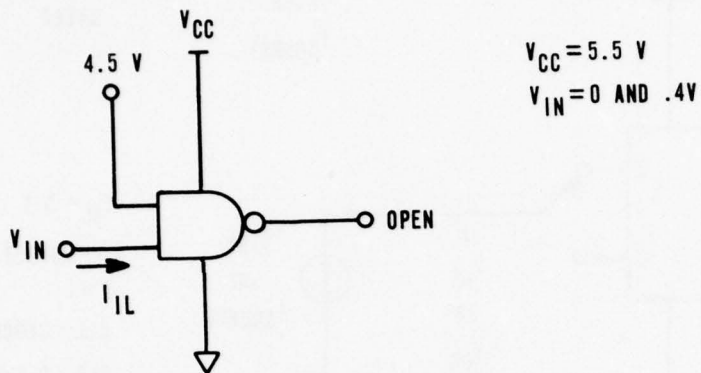


Figure B5. TTL Input Low Current ( $I_{IL}$ )

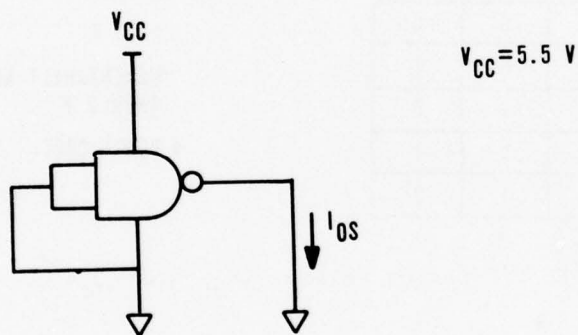


Figure B6. TTL Short Circuit Output Current ( $I_{OS}$ )

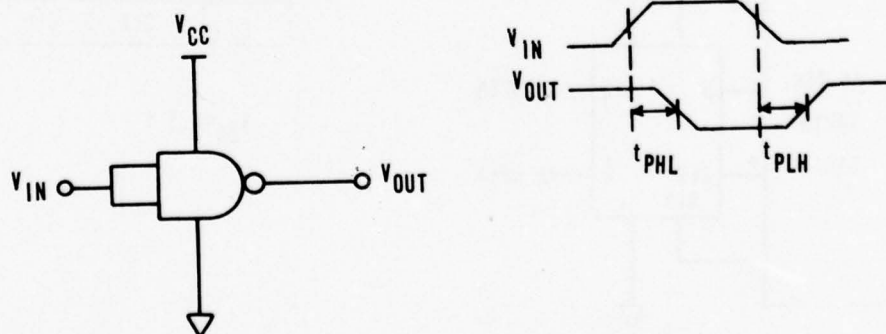
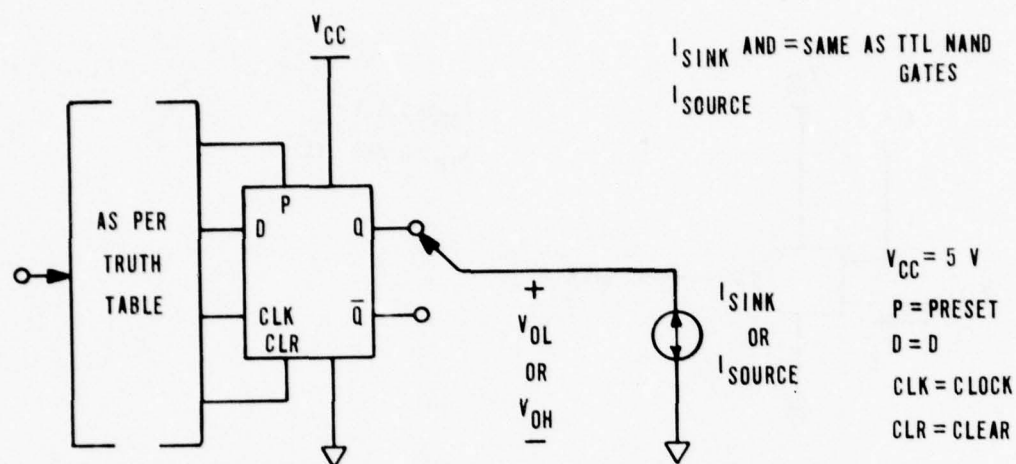


Figure B7. TTL Propagation Delay Times ( $T_{PHL}$ ,  $T_{PLH}$ )



TRUTH TABLE

P	CLR	CLK	D	Q	Q
0	1	X	X	0	1
1	0	X	X	1	0
1	1	1*	0	0	1
1	1	1*	1	1	0

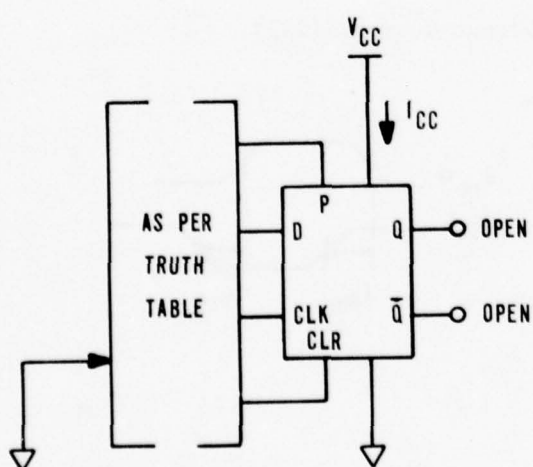
0 = .8 V

1 = 2 V

\*MOMENTARILY APPLY .4 V  
THEN 2 V

+ DON'T CARE

Figure 38. TTL F/F Output Voltage ( $V_{OL}$  and  $V_{OH}$ )

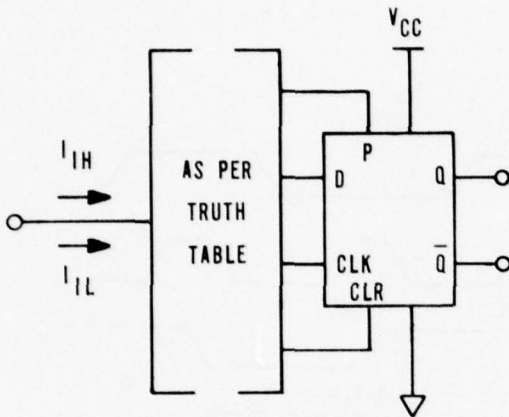


TEST	APPLY GND	OPEN
$I_{CC}$	CLK, D, P	CLR
$I_{CC}$	CLK, D, CLR	P

$V_{CC} = 4.5\text{ V}$

Figure 39 TTL F/F Power Supply Current ( $I_{CC}$ )





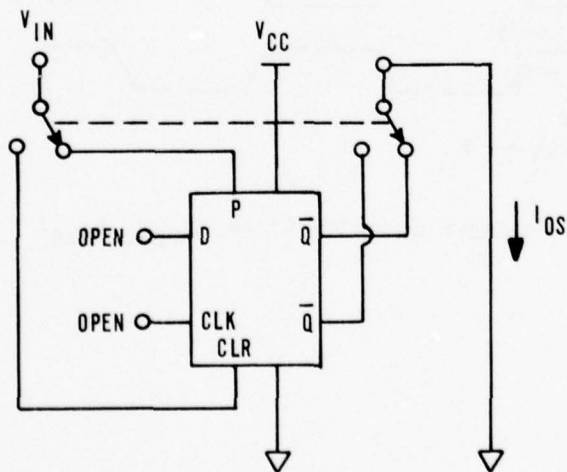
$V_{CC} = 5.5 \text{ V}$

\*MOMENTARILY APPLY GND  
THAN 4.5 V

APPLY 2.4 V AND 5.5 V TEST $I_{IH}$	APPLY 4.5 V	APPLY GND
CLK	CLR, D	P
CLK	P, D	CLR
P	CLR, D	CLK
CLR	P	D, CLK *
D	P, CLK	CLR

APPLY .4 V TEST $I_{IL}$	APPLY 4.5 V	APPLY GND
CLK	CLR	P, D
P	CLR	CLK, D
CLR	CLK, D, P	
D	CLR, CLK	P

Figure B10 TTL F/F Input Current ( $I_{IN}$ ,  $I_{IL}$ )



$V_{CC} = 5.5 \text{ V}$

$V_{IN} = \text{GND}$

Figure B11. TTL F/F Short Circuit Output Current ( $I_{OS}$ )

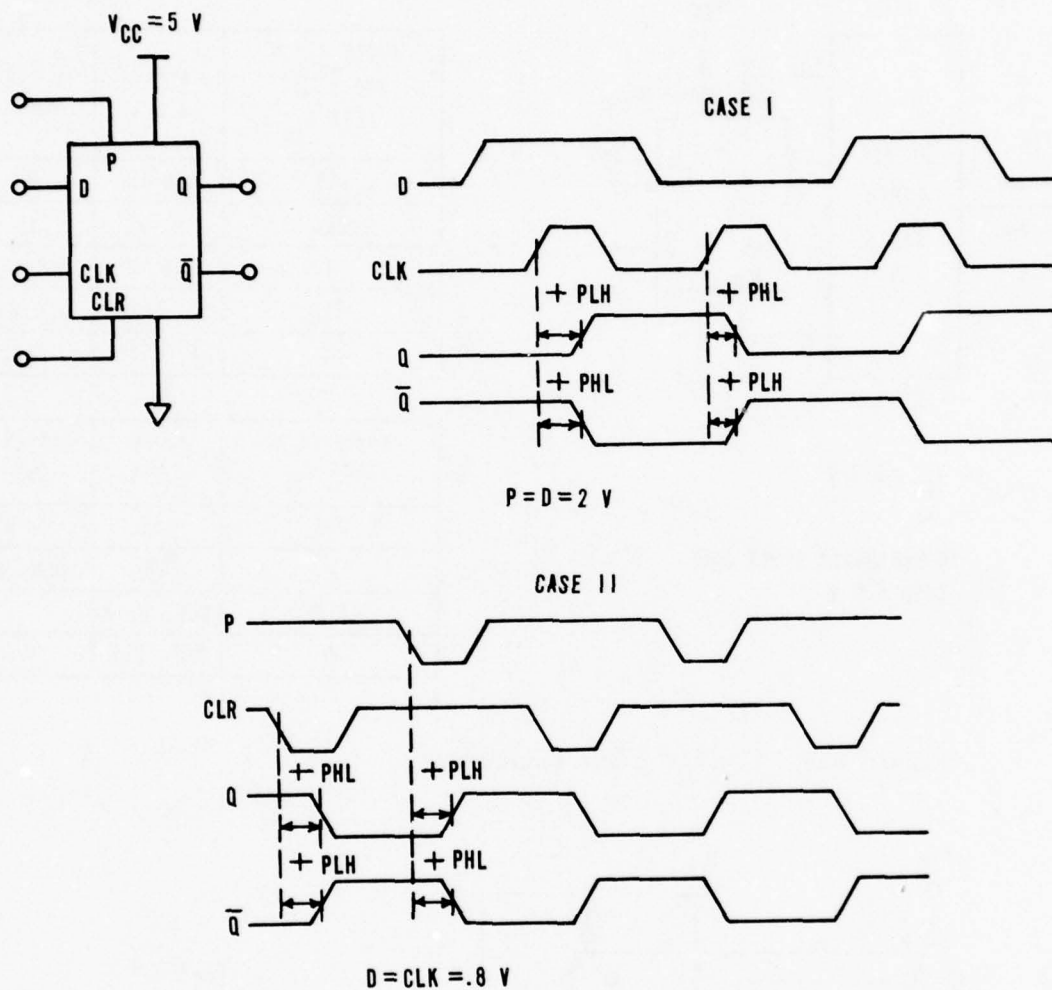


Figure B12. TTL F/F Propagation Delay Times ( $t_{PHL}$ ,  $t_{PLH}$ )

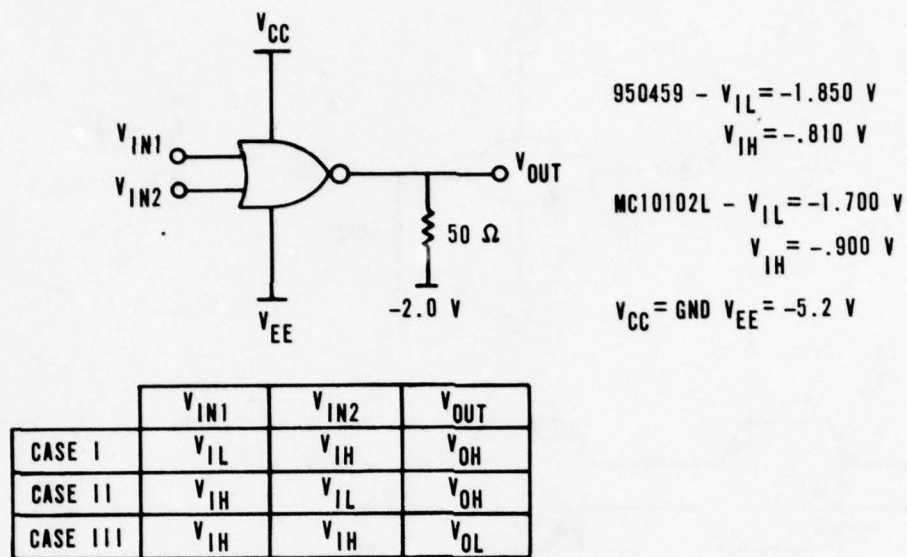


Figure B13. ECL Output Voltage ( $V_{OH}$ ,  $V_{OL}$ )

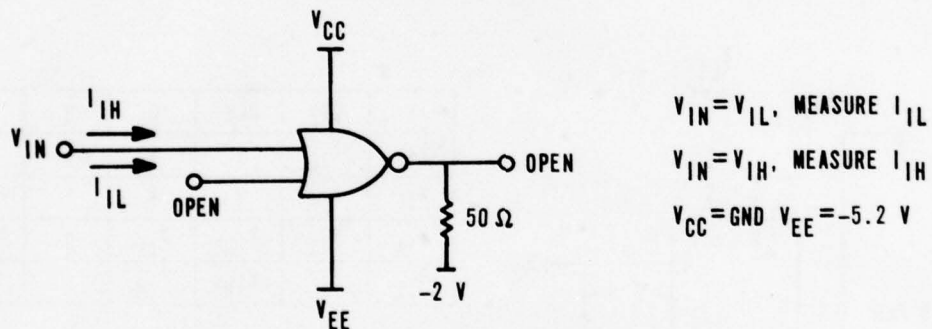


Figure B14. ECL Input Current ( $I_{IL}$ ,  $I_{IH}$ )

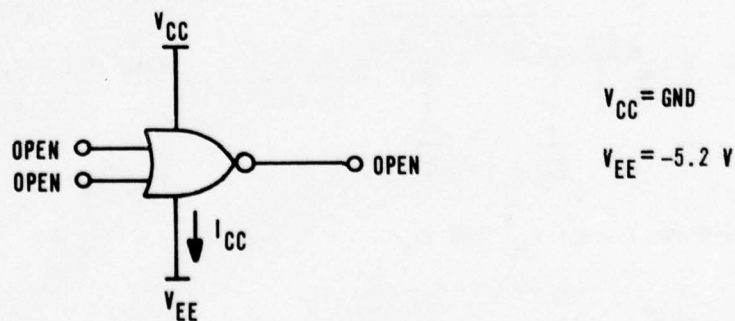


Figure B15. ECL Power Supply Current ( $I_{CC}$ )

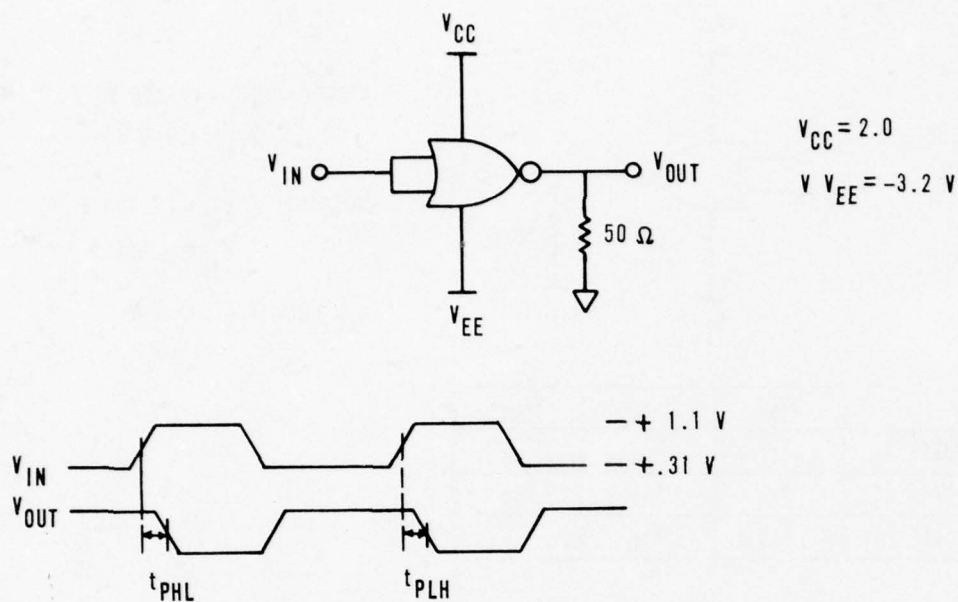


Figure B16. ECL Propagation Delay Time ( $t_{PHL}$ ,  $t_{PLH}$ )

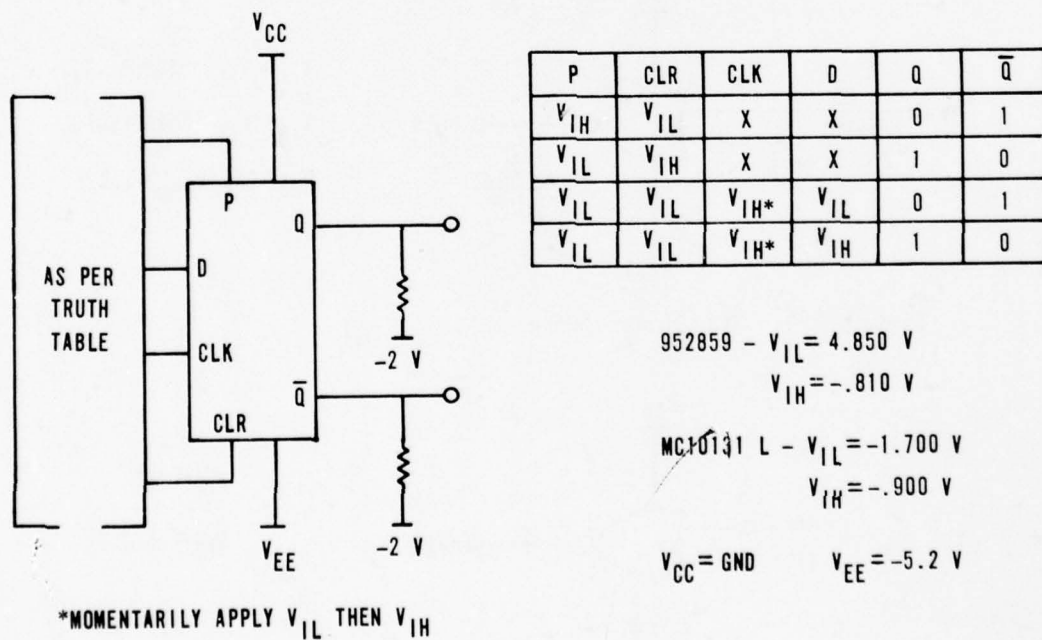


Figure B17. ECL F/F Output Voltage ( $V_{OH}$ ,  $V_{OL}$ )

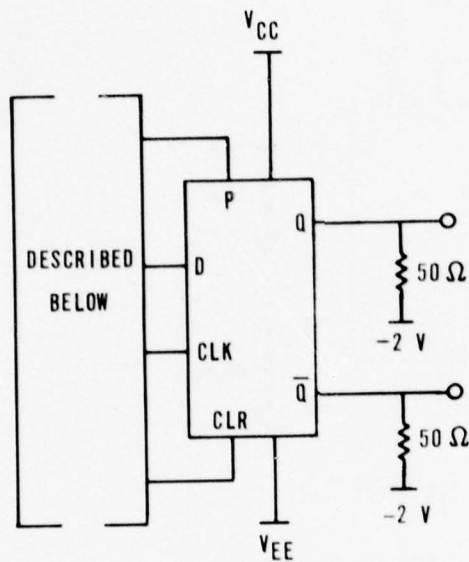


Figure B18. ECL F/F Current Measurements ( $I_{CC}$ ,  $I_{IH}$ ,  $I_{IL}$ )

A. Measure  $I_{CC}$  (Power Supply Current)

1. All inputs and outputs open
2.  $V_{CC} = GND$ ,  $V_{EE} \approx 5.2v$
3. Measure at  $V_{EE}$

B. Measure  $I_{IL}$  (Input Low Current)

1. All inputs =  $V_{IL}$  and outputs open.
2. Measure each input separately.
3.  $V_{CC} = GND$ ,  $V_{EE} \approx 5.2v$

C. Measure  $I_{IH}$  (Input High Current)

1. All inputs =  $V_{IH}$  and outputs open.
2. Measure each input separately.
3.  $V_{CC} = GND$ ,  $V_{EE} = -5.2v$



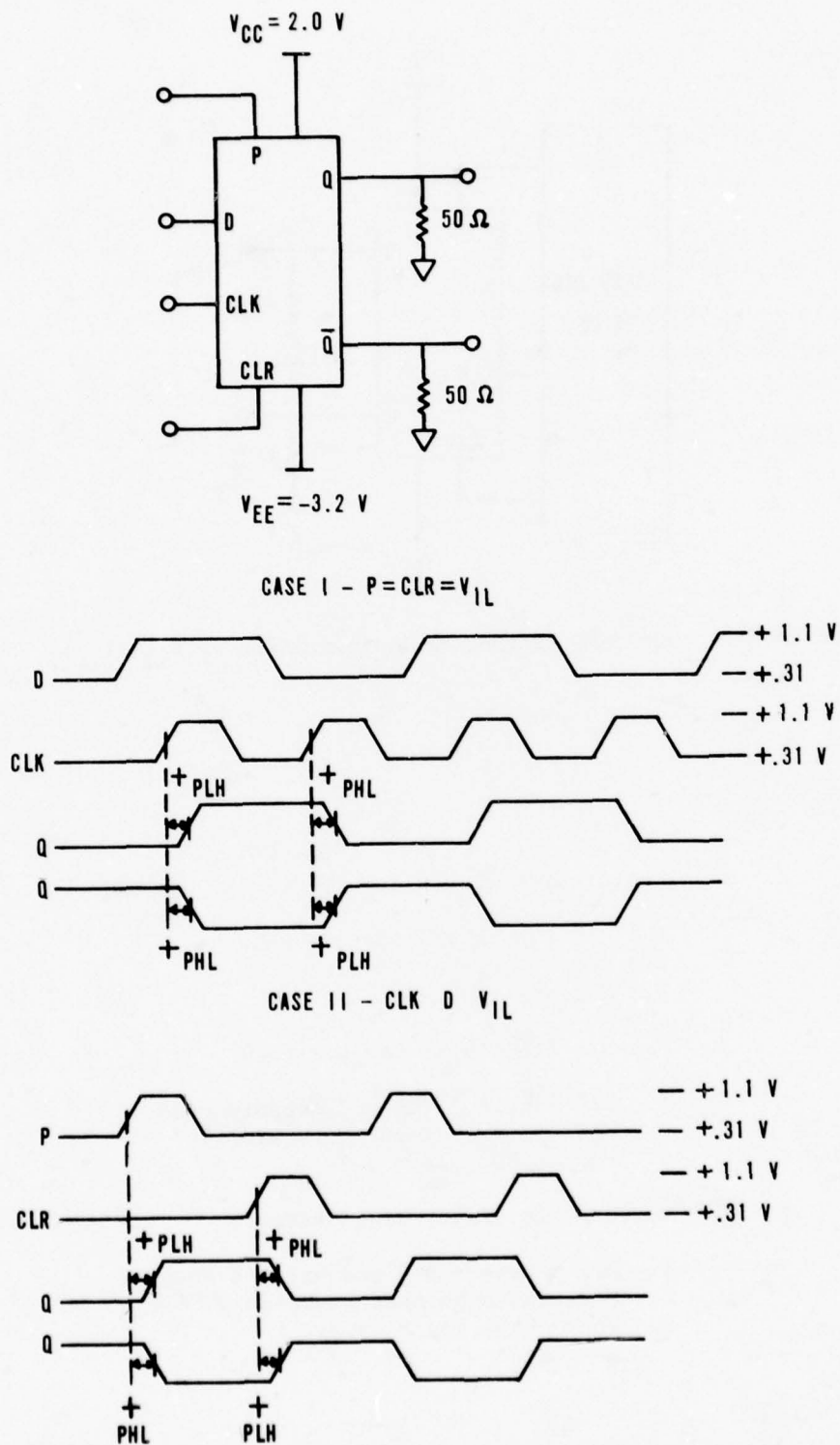


Figure B19. ECL F/F Propagation Delay Time ( $t_{PHL}$ ,  $t_{PLH}$ )

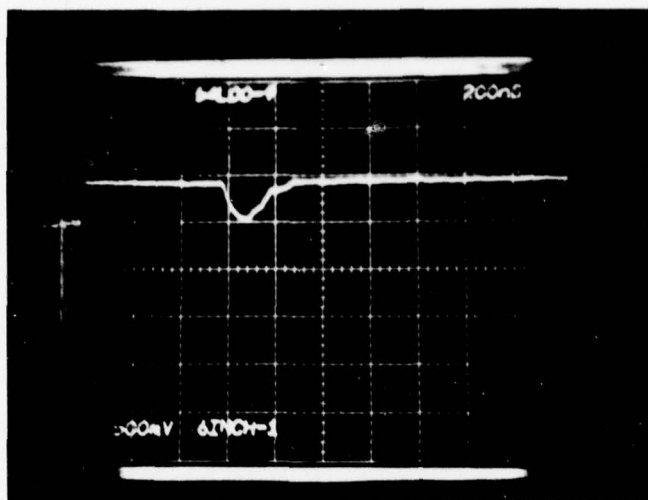
## APPENDIX C

### PHOTORESPONSE PHOTOGRAPHS

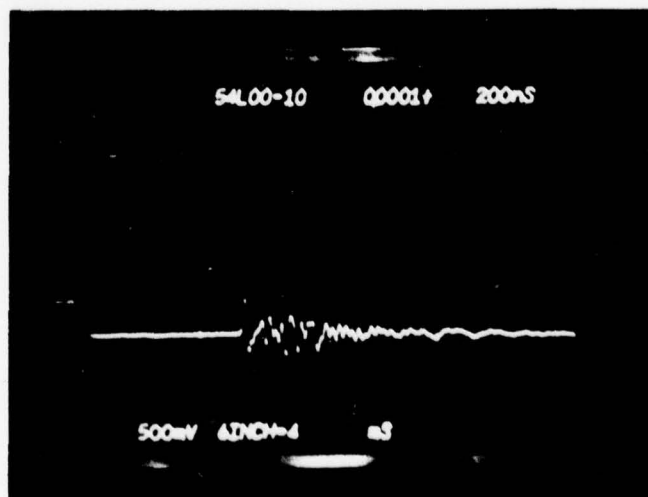
Figures C-1 through C-5 of this appendix illustrate the output photoresponse of the five TTL family NAND gates. These photographs illustrate characteristic dose-rate response of each TTL technology. As can be seen by these pictures, the Low Power and Low Power Schottky TTL technologies have a longer recovery time than the higher power Standard, High Speed and Schottky TTL technologies. The high current densities of the Standard, High Speed, and Schottky technologies more rapidly sweepout the hole-electron pairs generated during the transient radiation pulse.

Horizontal = 200 ns/div

Vertical = 0.5 v/div = 1 V div at the device



Output High Voltage ( $V_{OH}$ )

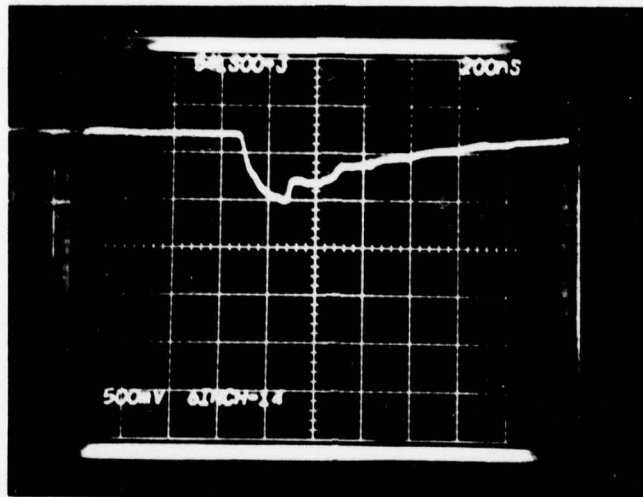


Output Low Voltage ( $V_{OL}$ )

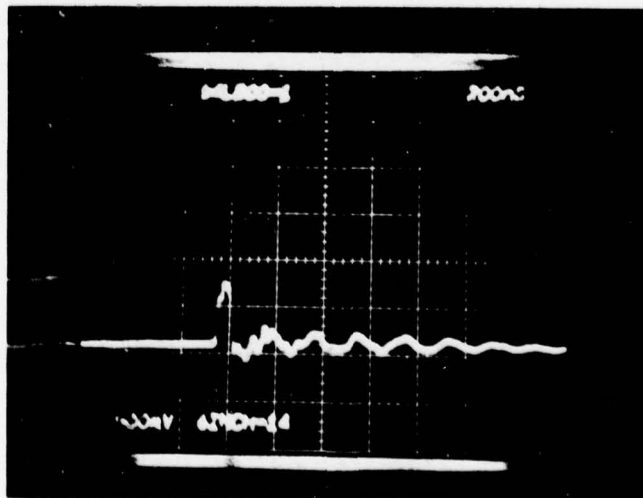
Figure C-1. TTL Low Power NAND Gate Photoresponse.

Horizontal = 200 ns/div

Vertical = 0.5 v/div = 1 V/div at the device



Output High Voltage ( $V_{OH}$ )

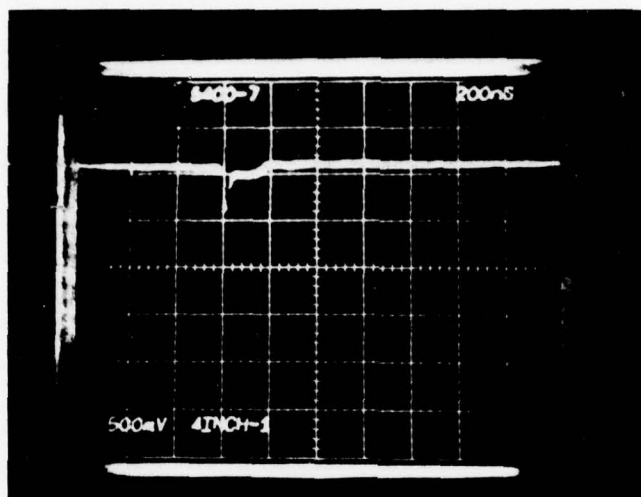


Output Low Voltage ( $V_{OL}$ )

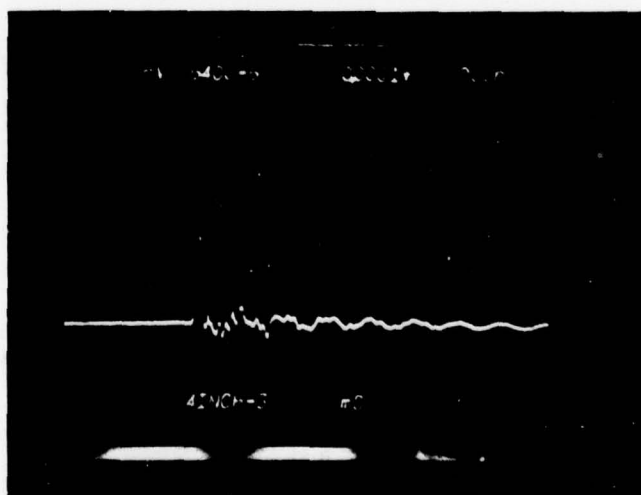
Figure C-2. TTL Low Power Schottky NAND Gate.

Horizontal = 200 ns/div

Vertical = 0.5V/div = 1V/div at the device



Output High Voltage ( $V_{OH}$ )



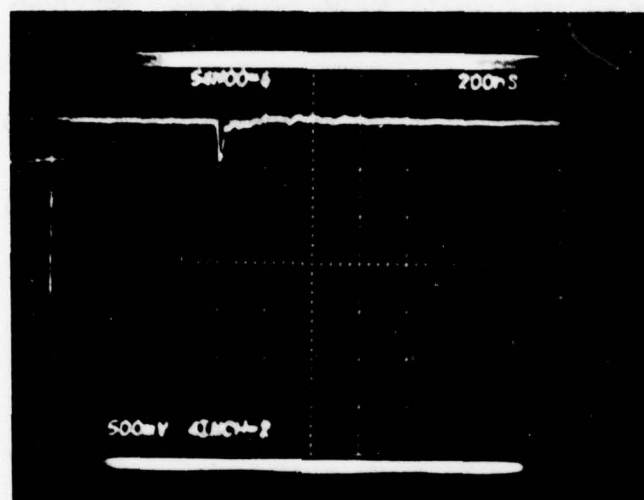
Output Low Voltage ( $V_{OL}$ )

Figure C-3. TTL Standard NAND Gate Photoresponse

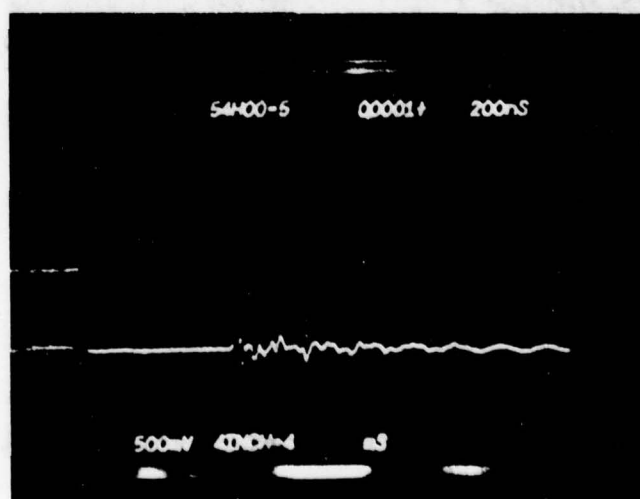


Horizontal = 200 ns/div

Vertical = 0.5 V/div = 1.V/div at the device



Output High Voltage ( $V_{OH}$ )

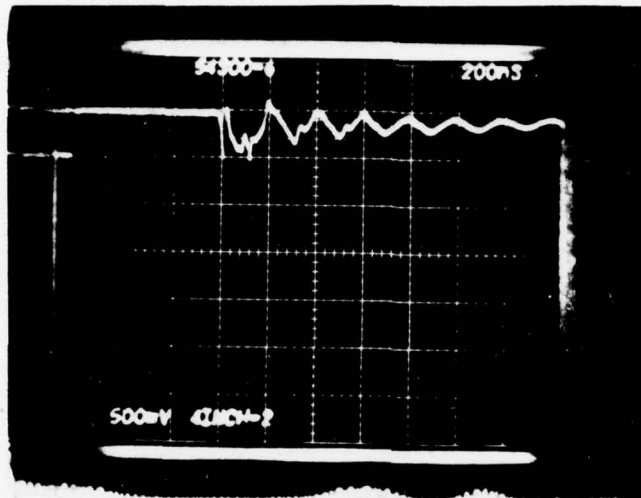


Output Low Voltage ( $V_{OL}$ )

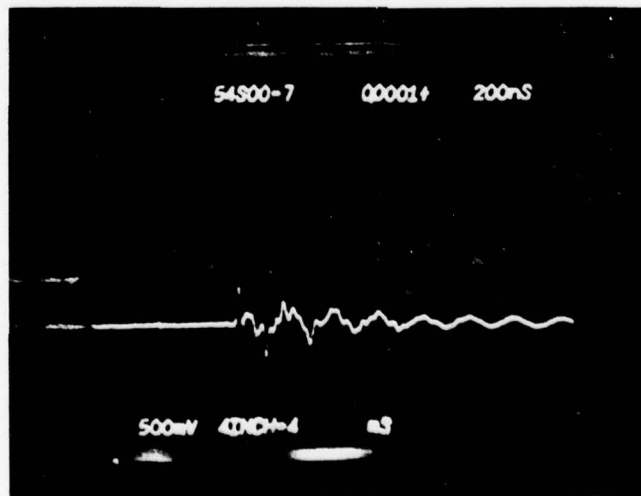
Figure C-4. TTL High Speed NAND Gate Photoresponse.

Horizontal = 200 ns/div

Vertical = 0.5 V/div = 1 V/div at the device



Output High Voltage ( $V_{OH}$ )



Output Low Voltage ( $V_{OL}$ )

Figure C-5. TTL Schottky NAND Gate Photoresponse.

APPENDIX D  
NEUTRON FLUENCE TEST DATA

This appendix contains the test data gathered on each device exposed to the neutron fluence irradiation. The data resulted from the electrical tests performed on the Fairchild 5000 integrated circuit tester following each incremental neutron irradiation. The data are presented in tables illustrating the specific electrical parameter measurements for each cumulative neutron fluence level. The units for each cumulative neutron fluence level are  $\text{n/cm}^2$ . Each electrical parameter listed shows the worst case measurement for that parameter. For example, each SN5400J NAND gate packaged dip contains four NAND gates. Hence the SN 5400J output low voltage measurements ( $V_{OL}$ ) shown on the table are the highest or worst case measurements of the four gates on that device. The Fairchild 5000 was not allowed to measure a voltage greater than 1.638 volts for the output low voltages of the TTL devices. However, this is sufficient since failure has already occurred at this point.

The measurements made on the SN54L00J devices do not include measurements made at  $4.6 \times 10^{14} \text{ n/cm}^2$  fluence level due to an error. However, measurements were made on the SN54L74J devices at this level. The measurements on the latter device showed that it failed at  $4.6 \times 10^{14} \text{ n/cm}^2$ . Thus, these data indicate that the output failure threshold for the low power TTL technology lies between  $1.4 \times 10^{14}$  and  $4.6 \times 10^{14} \text{ n/cm}^2$ . Also note that the ECL NOR gates were tested at only the higher neutron fluence levels. Since data had already been gathered on the ECL D flip-flops, time was saved by irradiating first at higher neutron fluences. The propagation delay time measurements shown on the tables are not valid for the cumulative neutron fluences at which the output voltages failed.

## MEASUREMENTS ON DEVICE NUMBER 1, DEVICE TYPE 950459

TEST		PRE RAD	.57E+15	1.0E+15
VOL	(VOLTS)	-1.661	-1.596	-1.528
VOH	(VOLTS)	- .9197	- .9776	-1.191
ICC	(MILLIAMPS)	52.92	47.21	39.83
IIL	(MILLIAMPS)	1.712	1.716	1.789
I1H	(MILLIAMPS)	2.195	2.510	2.792
TPHL	(NANOSEC)	4.12	2.97	1.05
TPHL	(NANOSEC)	3.70	2.42	1.97
TPLH	(NANOSEC)	3.80	3.90	*
TPLH	(NANOSEC)	3.77	3.72	*

\* Measurements are not valid due to the shift in output voltage.

MEASUREMENTS ON DEVICE NUMBER 2, DEVICE TYPE 950459

TEST		PRE RAD	.57E+15	1.0E+15
VOL	(VOLTS)	-1.688	-1.627	-1.559
VOH	(VOLTS)	- .9287	- .9776	-1.552
ICC	(MILLIAMPS)	48.07	43.80	37.82
IIL	(MILLIAMPS)	1.569	1.566	1.584
I1H	(MILLIAMPS)	1.968	2.218	2.489
TPHL	(NANOSEC)	3.65	2.85	1.75
TPHL	(NANOSEC)	3.40	2.57	1.57
TPLH	(NANOSEC)	3.72	3.75	*
TPLH	(NANOSEC)	3.55	3.65	*

\* Measurements are not valid due to the shift in output voltage.



## MEASUREMENTS ON DEVICE NUMBER 3, DEVICE TYPE 950459

TEST		PRE RAD	.57E+15	1.0E+15
VOL	(VOLTS)	-1.696	-1.581	-1.509
VOH	(VOLTS)	- .9233	-1.012	-1.305
ICC	(MILLIAMPS)	52.36	45.70	37.49
IIL	(MILLIAMPS)	1.772	1.769	1.973
I1H	(MILLIAMPS)	2.315	2.672	2.932
TPHL	(NANOSEC)	3.35	2.35	1.07
TPHL	(NANOSEC)	3.77	2.10	1.00
TPLH	(NANOSEC)	4.12	3.82	*
TPLH	(NANOSEC)	3.67	3.77	*

\* Measurements are not valid due to the shift in output voltage.

## MEASUREMENTS ON DEVICE NUMBER 1, DEVICE TYPE MC10102L

TEST		PRE RAD	.57E+15	1.0E+15
VOL	(VOLTS)	-1.713	-1.690	-1.665
VOH	(VOLTS)	- .8993	- .9516	-1.117
ICC	(MILLIAMPS)	21.10	19.32	18.50
IIL	(MICROAMPS)	35.04	31.66	27.69
I1H	(MILLIAMPS)	.1426	.1623	.3066
TPHL	(NANOSEC)	3.00	2.60	2.50
TPHL	(NANOSEC)	2.80	2.45	2.00
TPLH	(NANOSEC)	1.00	1.25	1.60
TPLH	(NANOSEC)	1.00	1.40	1.90

## MEASUREMENTS ON DEVICE NUMBER 2, DEVICE TYPE MC10102L

TEST		PRE RAD	.57E+15	1.0E+15
VOL	(VOLTS)	-1.702	-1.672	-1.642
VOH	(VOLTS)	- .9310	-1.016	-1.1520
ICC	(MILLIAMPS)	20.82	19.12	18.38
IIL	(MICROAMPS)	70.45	65.50	61.28
IIH	(MILLIAMPS)	.1400	.2371	.3924
TPHL	(NANOSEC)	3.00	2.50	1.90
TPHL	(NANOSEC)	3.20	3.00	2.40
TPLH	(NANOSEC)	1.20	1.42	1.60
TPLH	(NANOSEC)	1.50	2.00	2.70

## MEASUREMENTS ON DEVICE NUMBER 3, DEVICE TYPE MC10102L

TEST		PRE RAD	.57E+15	1.07E+15
VOL	(VOLTS)	-1.732	-1.701	-1.640
VOH	(VOLTS)	- .9090	-1.010	-1.276
ICC	(MILLIAMPS)	20.97	19.50	18.37
IIL	(MICROAMPS)	38.99	35.63	31.51
I1H	(MILLIAMPS)	.1164	.2115	.3028
TPHL	(NANOSEC)	2.70	2.53	2.50
TPHL	(NANOSEC)	2.70	2.95	2.90
TPLH	(NANOSEC)	1.30	1.75	1.90
TPLH	(NANOSEC)	1.00	2.00	2.30

THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDC

## MEASUREMENTS ON DEVICE NUMBER 1, DEVICE TYPE SN=400J

TEST	PRE PAD	.28E+13	.69E+14	.14E+15	.46E+15	.73E+15
VOL (VOLTS)	.1496	.1505	.1696	.1972	.2733	1.6330
VON (VOLTS)	3.234	3.233	3.212	3.197	3.145	3.126
ICC (MILLIAMPS)	5.00	5.00	4.99	4.96	4.92	4.86
IOS (MILLIAMPS)	38.60	18.56	37.72	37.04	25.57	18.12
IIL (MILLIAMPS)	1.130	1.129	1.124	1.120	1.104	1.089
ITM (MICROAMPS)	9.72	9.62	7.70	6.36	2.87	1.63
TPHL (NANOSEC)	5.22	5.35	5.62	5.47	7.62	8.82
TPHL (NANOSEC)	5.52	5.65	5.65	5.70	8.10	9.25
TPLM (NANOSEC)	14.85	14.90	13.12	12.40	11.20	10.22
TPLM (NANOSEC)	14.75	14.80	13.30	12.05	11.55	10.60



THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDC

## MEASUREMENTS ON DEVICE NUMBER 2, DEVICE TYPE SN5400J

TEST	PPE RAD	.28E+13	.69E+14	.14E+15	.46E+15	.73E+15
VOL (VOLTS)	.1876	.1879	.2156	.2439	1.6380	1.6380
VOH (VOLTS)	3.163	3.162	3.125	3.113	3.036	3.009
ICC (MILLIAMPS)	4.62	4.62	4.60	4.59	4.53	4.46
IOS (MILLIAMPS)	35.99	35.98	34.49	33.28	15.03	10.32
IIL (MILLIAMPS)	1.034	1.037	1.026	1.026	1.012	.989
IIH (MICROAMPS)	2.01	1.98	1.51	1.16	.33	.14
TPHL (NANOSEC)	6.47	6.82	7.47	7.57	12.57	15.25
TPHL (NANOSEC)	6.95	7.02	7.62	8.00	13.10	16.75
TPLH (NANOSEC)	14.67	14.65	12.92	12.15	10.80	20.72
TPLH (NANOSEC)	14.70	14.42	12.90	11.85	11.15	20.72

THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDC

## MEASUREMENTS ON DEVICE NUMBER 3, DEVICE TYPE SN5400J

TEST	PRE RAD	.28E+13	.69E+14	.14E+15	.46E+15	.73E+15
VOL (VOLTS)	.1361	.1392	.1604	.1825	.3023	1.6380
VOM (VOLTS)	3.240	3.224	3.214	3.201	3.134	3.116
ICC (MILLIAMPS)	5.38	5.37	5.36	5.34	5.20	5.22
IOS (MILLIAMPS)	34.99	34.24	34.17	33.63	23.97	16.69
IIL (MILLIAMPS)	1.208	1.200	1.200	1.196	1.110	1.161
IIH (MICROAMPS)	12.07	11.64	9.06	7.07	2.58	1.31
TPHL (NANOSEC)	5.47	5.62	5.95	6.05	8.70	10.15
TPHL (NANOSEC)	5.55	6.07	6.22	6.05	9.02	10.82
TPLH (NANOSEC)	20.35	19.22	14.85	13.25	11.07	10.70
TPLH (NANOSEC)	20.42	18.77	14.85	13.22	11.40	10.70

THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDC

## MEASUREMENTS ON DEVICE NUMBER 1, DEVICE TYPE SN5474J

TEST	PRE PAD	.28E+13	.69E+14	.14E+15	.46E+15	.73E+15
VOL (VOLTS)	.2412	.2382	.2577	.2880	1.6380	1.6380
VOL (VOLTS)	3.271	3.241	3.224	3.232	3.155	3.150
ICC (MILLIAMPS)	20.55	20.51	20.45	20.36	20.07	19.76
IOS (MILLIAMPS)	36.29	36.09	35.03	31.22	17.95	12.87
ITL (MILLIAMPS)	4.531	4.518	4.504	4.491	4.428	4.389
ITH (MICROAMPS)	2.40	2.76	2.33	1.86	1.50	.48
TOHL (NSEC-CLOCK)	19.90	20.22	19.60	7.80	21.97	40.00
TOHL (NSEC-CLEAR)	24.45	25.15	24.52	25.30	28.07	40.00
TOHL (NSEC-CLOCK)	15.20	15.60	15.40	12.80	15.20	21.50
TOHL (NSEC-PRESET)	21.37	22.02	21.50	21.80	25.40	32.70

THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDC

## MEASUREMENTS ON DEVICE NUMBER 2, DEVICE TYPE SN5474J

TEST	PRE PAD	.24E+13	.69E+14	.14E+15	.46E+15	.73E+15
VOL (VOLTS)	.2647	.2676	.2816	.3124	1.6380	1.6380
VOM (VOLTS)	3.319	3.239	3.266	3.279	3.193	3.180
ICC (MILLIAMPS)	18.99	18.64	18.92	18.85	18.61	18.37
IOS (MILLIAMPS)	33.42	32.02	32.80	30.33	17.45	12.59
IIL (MILLIAMPS)	4.203	4.124	4.187	4.174	4.128	4.082
IIM (MICROAMPS)	2.20	2.12	1.90	1.61	1.40	.59
TDPL (NSEC-CLOCK)	20.00	19.80	18.92	15.50	21.70	40.00
TDHL (NSEC-CLEAR)	24.57	24.47	23.75	24.10	27.50	40.00
TOLM (NSEC-CLOCK)	14.60	14.70	14.50	11.10	14.90	21.30
TOLM (NSEC-PRESET)	20.57	21.10	20.67	21.00	24.50	29.30

THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDC

## MEASUREMENTS ON DEVICE NUMBER 3, DEVICE TYPE SN5474J

TEST	PRE RAD	.28E+13	.69E+14	.14E+15	.46E+15	.73E+15
VOL (VOLTS)	.2676	.2719	.2983	.3264	1.6380	1.6380
VOH (VOLTS)	3.247	3.224	3.195	3.206	3.098	3.089
ICC (MILLIAMPS)	20.10	20.05	19.96	19.91	19.53	19.29
IOS (MILLIAMPS)	34.87	34.64	33.12	27.88	14.40	10.25
ITL (MILLIAMPS)	4.402	4.392	4.374	4.368	4.309	4.253
IIM (MICROAMPS)	2.10	1.14	.96	.78	.50	.14
TDHL (NSEC-CLOCK)	19.70	19.40	19.40	16.60	22.70	40.00
TDPL (NSEC-CLEAR)	24.47	24.47	24.00	23.50	29.30	40.00
TDLM (NSEC-CLOCK)	13.40	14.40	14.10	10.60	15.10	28.40
TDPM (NSEC-PRESET)	21.17	20.40	19.90	21.40	26.40	34.80



THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDG

## MEASUREMENTS ON DEVICE NUMBER 1 • DEVICE TYPE SN-4L00J

TEST	PRE P40	.25E+13	.59E+14	.14E+15	.73E+15
VOL (VOLTS)	.1635	.1641	.1927	.2304	1.0003
VOL (VOLTS)	3.234	3.234	3.160	3.103	2.743
ICC (MILLIAMPS)	.65	.65	.64	.64	.6
IOS (MILLIAMPS)	10.71	10.51	9.61	4.69	.9
IIL (MILLIAMPS)	.150	.150	.149	.148	.163
IIF (MICROAMPS)	.36	.35	.26	.20	.05
TDEL (NANOSEC)	35.20	35.30	38.97	41.82	60.92
TDEL (NANOSEC)	36.70	36.57	40.70	44.77	60.92
TPLH (NANOSEC)	19.35	18.32	41.90	44.30	60.92
TPLH (NANOSEC)	19.20	14.10	40.20	44.50	60.92

THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDG

## MEASUREMENTS ON DEVICE NUMBER 2, DEVICE TYPE SN=4L00J

TEST	PRE QAD	.28E+13	.69E+14	.14E+15	.73E+15
VOL (VOLTS)	.1533	.1544	.1771	.2015	1.5380
VOM (VOLTS)	3.248	3.244	3.175	3.126	2.778
ICC (MILLIAMPS)	.44	.44	.44	.44	.4
IOS (MILLIAMPS)	9.11	9.10	7.05	4.94	1.1
IIL (MILLIAMPS)	.103	.103	.102	.101	.007
IIT (MICROAMPS)	.48	.48	.37	.26	.1
TPHL (NANOSEC)	38.40	38.67	40.30	41.90	54.30
TPHL (NANOSEC)	40.67	40.77	37.60	44.60	59.27
TPLH (NANOSEC)	22.60	20.37	13.37	41.90	60.00
TPLH (NANOSEC)	22.60	20.70	14.22	42.60	60.00

THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDG

## MEASUREMENTS ON DEVICE NUMBER 3, DEVICE TYPE SN=4L00J

TEST	PRE RAD	.26E+13	.69E+14	.14E+15	.73E+15
VOL (VOLTS)	.1555	.1559	.1804	.2051	1.5380
VOH (VOLTS)	3.255	3.251	3.179	3.126	2.752
ICC (MILLIAMPS)	.44	.44	.43	.43	.41
IOS (MILLIAMPS)	8.99	8.96	7.40	5.05	1.11
IIL (MILLIAMPS)	.103	.102	.101	.101	.095
IIM (MICROAMPS)	.44	.42	.33	.23	.11
TPHL (NANOSEC)	37.00	36.95	39.60	41.32	56.55
TPHL (NANOSEC)	36.42	38.77	41.40	44.30	60.70
TPLH (NANOSEC)	24.30	23.22	14.22	44.15	60.00
TPLH (NANOSEC)	24.50	22.50	13.70	44.80	60.00

THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDC

## MEASUREMENTS ON DEVICE NUMBER 1, DEVICE TYPE SN54L74J

TEST	PHE PAD	.28E+13	.69E+14	.14E+15	.46E+15	.73E+15
VOL (VOLTS)	.1728	.1712	.1889	.2083	1.6380	1.6380
V <sub>OH</sub> (VOLTS)	3.625	3.610	3.562	3.505	3.052	2.701
ICC (MILLIAMPS)	1.19	1.18	1.17	1.16	1.14	1.12
I <sub>OS</sub> (MILLIAMPS)	6.93	6.74	6.28	4.53	1.64	1.08
I <sub>IL</sub> (MILLIAMPS)	.296	.293	.292	.290	.286	.282
I <sub>TH</sub> (MICROAMPS)	.62	.61	.52	.44	.40	.16
T <sub>PHL</sub> (NSEC-CLOCK)	151.00	153.00	160.00	169.00	235.00	310.00
T <sub>PHL</sub> (NSEC-CLEAR)	112.00	113.00	118.00	123.00	243.00	850.00
T <sub>PLH</sub> (NSEC-CLOCK)	124.00	125.00	127.00	127.00	872.00	872.00
T <sub>PLH</sub> (NSEC-PRESET)	47.00	48.00	47.00	49.00	27.00	850.00

THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDC

## MEASUREMENTS ON DEVICE NUMBER 2, DEVICE TYPE SN54L74J

TEST	PRE	RAD	.28E+13	.69E+14	.14E+15	.46E+15	.73E+15
VOL (VOLTS)		.1672	.1631	.1783	.1907	.9271	1.6380
VOL (VOLTS)		3.613	3.610	3.560	3.508	3.142	2.750
ICC (MILLIAMPS)		1.65	1.65	1.64	1.63	1.60	1.57
IOS (MILLIAMPS)		7.95	7.91	7.60	5.97	2.42	1.60
IIL (MILLIAMPS)		.396	.395	.393	.392	.345	.379
IIM (MICROAMPS)		1.50	1.38	1.26	1.15	.92	.55
TDHL (NSEC-CLOCK)		181.00	122.00	127.00	134.00	176.00	224.00
TDHL (NSEC-CLFAR)		90.00	92.00	94.00	102.00	133.00	708.00
TPLH (NSEC-CLOCK)		98.00	100.00	101.00	104.00	872.00	871.00
TPLH (NSEC-PRESET)		42.00	43.00	42.00	44.00	90.00	850.00



THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDC

## MEASUREMENTS ON DEVICE NUMBER 3, DEVICE TYPE SN54L74J

TEST	PRE RAD	.28E+13	.69E+14	.14E+15	.46E+15	.73E+15
VOL (VOLTS)	.1871	.1863	.2037	.2272	1.6380	1.6380
VOH (VOLTS)	3.645	3.644	3.572	3.502	3.055	2.675
ICC (MILLIAMPS)	1.12	1.12	1.11	1.10	1.04	1.06
IOS (MILLIAMPS)	6.17	6.12	5.74	4.19	1.60	1.07
IIL (MILLIAMPS)	.272	.270	.268	.267	.262	.257
ITH (MICROAMPS)	.41	.38	.32	.28	.22	.11
TPHL (NSEC-CLOCK)	147.00	148.00	154.00	165.00	231.00	850.00
TPHL (NSEC-CLEAR)	109.00	110.00	115.00	250.00	262.00	850.00
TPLH (NSEC-CLOCK)	126.00	128.00	127.00	300.00	872.00	850.00
TPLH (NSEC-PRESET)	48.00	46.00	47.00	47.00	232.00	850.00

THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDC

## MEASUREMENTS ON DEVICE NUMBER 1, DEVICE TYPE SN54H00J

TEST	PRF	PAD	.28E+13	.69E+14	.14F+15	.46E+15	.73E+15	.12F+16
VOL (VOLTS)		.2619	.2627	.2819	.2863	.3165	.4584	1.6380
VCH (VOLTS)		3.119	3.116	3.092	3.090	3.049	3.029	2.978
ICC (MILLIAMPS)		11.25	11.26	11.16	11.13	10.92	10.85	10.71
IOS (MILLIAMPS)		51.60	51.91	51.28	50.84	51.24	55.71	55.61
ITL (MILLIAMPS)		1.453	1.453	1.438	1.438	1.419	1.405	1.381
ITM (MICROAMPS)		3.56	3.46	3.10	2.88	1.62	1.27	.59
TPHL (NANOSEC)		5.27	5.17	5.50	5.20	6.70	6.37	10.37
TPHL (NANOSEC)		5.40	5.55	5.60	5.55	6.95	6.72	11.30
TPH (NANOSEC)		10.05	9.82	9.27	8.75	8.02	7.10	6.12
TPH (NANOSEC)		10.05	9.90	9.35	8.80	8.60	7.33	6.27

## MEASUREMENTS ON DEVICE NUMBER 2, DEVICE TYPE SN=4H00J

TEST	PPE PAD	.28E+13	.69E+14	.14E+15	.46E+15	.73E+15	.12E+16
VOL (VOLTS)	.2343	.2360	.2481	.2601	.3197	1.2799	1.6383
VCH (VOLTS)	3.122	3.114	3.104	3.100	3.006	3.011	2.953
ICC (MILLIAMPS)	12.84	12.85	12.77	12.73	12.57	12.40	12.20
IOS (MILLIAMPS)	50.27	50.59	49.96	49.56	49.87	54.23	54.08
ITL (MILLIAMPS)	1.659	1.651	1.649	1.643	1.624	1.604	1.561
ITM (MICROAMPS)	5.16	5.05	4.46	3.99	1.97	1.20	.39
TDHL (NANOSEC)	6.32	6.32	6.57	6.62	8.75	8.50	14.05
TDHL (NANOSEC)	6.27	9.90	7.00	6.62	8.92	8.95	15.37
TDLM (NANOSEC)	10.12	10.15	9.70	9.20	8.47	7.57	8.30
TDLM (NANOSEC)	9.80	9.90	9.60	9.32	8.72	7.75	8.60

THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDC

## MEASUREMENTS ON DEVICE NUMBER 3, DEVICE TYPE SN=4H00J

TEST	PRE	RAD	.28E+13	.69E+14	.14E+15	.46E+15	.73E+15	.12E+16
VOL (VOLTS)		.2393	.2399	.2583	.2689	.3224	1.0285	1.6380
VOM (VOLTS)		3.120	3.119	3.076	3.091	3.040	3.025	2.966
ICC (MILLIAMPS)		11.25	11.27	11.13	11.14	11.00	10.87	10.71
IOS (MILLIAMPS)		51.49	51.81	51.17	50.81	51.13	55.57	55.45
ITL (MILLIAMPS)		1.448	1.451	1.424	1.435	1.420	1.404	1.367
ITM (MICROAMPS)		2.80	2.72	2.40	2.16	1.08	.73	.29
TPHL (NANOSEC)		5.27	5.22	5.60	5.42	7.10	6.87	11.50
TPHL (NANOSEC)		5.30	5.60	5.77	5.45	7.32	7.32	12.67
TPH (NANOSEC)		9.82	9.80	9.17	8.77	7.75	7.10	7.52
TPH (NANOSEC)		9.95	9.92	9.22	9.00	7.97	7.07	7.42

THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDC

## MEASUREMENTS ON DEVICE NUMBER 1, DEVICE TYPE SN54H74J

TEST	PWE RAD	.28E+13	.69E+14	.14E+15	.46E+15	.73E+15
VOL (VOLTS)	.2399	.2392	.2495	.2695	.4321	1.6380
VOM (VOLTS)	2.938	2.905	2.882	2.882	2.819	2.520
ICC (MILLIAMPS)	32.73	32.67	32.59	32.44	31.80	51.73
IOS (MILLIAMPS)	63.01	62.84	62.21	61.45	58.60	56.29
IIL (MILLIAMPS)	5.607	5.602	5.604	5.606	5.587	5.553
ITM (MICROAMPS)	7.20	7.17	5.66	4.17	1.62	.33
TDHL (NSEC-CLOCK)	10.40	11.20	10.45	10.92	10.00	10.62
TDHL (NSEC-CLEAR)	22.37	22.32	21.95	22.70	24.82	38.20
TDLM (NSEC-CLOCK)	26.80	30.00	25.00	29.60	19.90	16.00
TDLM (NSEC-PRESET)	14.47	14.25	13.75	14.17	12.57	10.52



THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDG

## MEASUREMENTS ON DEVICE NUMBER 2, DEVICE TYPE SN54H74J

TEST	PPE RAD	.28E+13	.69E+14	.14E+15	.46E+15	.73E+15
VOL (VOLTS)	.2469	.2407	.2539	.2671	.3798	1.6380
VCH (VOLTS)	2.906	2.843	2.867	2.873	2.808	2.641
ICC (MILLIAMPS)	35.33	35.24	35.16	35.02	34.42	46.40
IOS (MILLIAMPS)	66.34	66.19	65.45	64.58	61.63	59.19
ITL (MILLIAMPS)	6.143	6.142	6.144	6.142	6.125	6.088
IIM (MICROAMPS)	14.00	8.97	7.33	5.85	1.91	.83
TOHL (NSEC-CLOCK)	9.40	9.95	9.62	10.37	9.02	9.10
TOHL (NSEC-CLEAR)	20.55	20.32	20.25	21.02	21.62	19.70
TOHL (NSEC-CLOCK)	26.20	24.00	27.40	27.60	17.50	14.60
TOHL (NSEC-PRESET)	14.25	14.00	13.52	14.57	12.80	8.87

THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDC

## MEASUREMENTS ON DEVICE NUMBER 3, DEVICE TYPE SN54H74J

TEST	PRE	READ	.28E+13	.69E+14	.14E+15	.46E+15	.73E+15
VOL (VOLTS)		.2359	.2420	.2495	.2668	.4260	1.6380
VOH (VOLTS)		2.430	2.905	2.904	2.900	2.813	2.727
ICC (MILLIAMPS)		35.25	35.20	35.06	34.92	34.30	39.15
IOS (MILLIAMPS)		64.32	63.43	63.42	62.65	59.84	57.45
IIL (MILLIAMPS)		5.767	5.744	5.758	5.758	5.749	5.712
IIM (MICROAMPS)		14.00	9.54	7.99	6.45	2.81	1.04
TPHL (NSEC-CLOCK)		14.30	14.02	13.25	14.00	12.47	10.00
TDHL (NSEC-CLEAR)		20.92	20.80	20.42	22.15	22.25	20.00
TDLH (NSEC-CLOCK)		9.72	10.52	9.87	10.60	8.92	9.52
TDLH (NSEC-PRESET)		29.60	29.50	25.00	22.00	17.70	16.12

THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDC

## MEASUREMENTS ON DEVICE NUMBER 1, DEVICE TYPE SN:4500J

TEST	PHE RAD	.28E+13	.69E+14	.14E+15	.46E+15	.73E+15	.12E+16	.20E+16
VOL (VOLTS)	.3999	.4027	.4152	.4166	.427	.4806	.5216	1.5000
VOM (VOLTS)	3.460	3.460	3.449	3.449	3.333	3.384	3.318	3.240
ICC (MILLIAMPS)	12.79	12.79	12.73	12.72	12.60	12.49	12.36	12.14
I <sub>OS</sub> (MILLIAMPS)	51.01	50.88	50.76	50.49	50.81	55.22	54.95	56.52
IIL (MILLIAMPS)	1.636	1.634	1.630	1.631	1.620	1.614	1.601	1.546
IIM (MICROAMPS)	.07	.09	.09	.06	.07	.09	.09	.07
TPHL (NANOSEC)	2.95	2.87	2.95	2.55	3.07	2.20	3.87	5.82
TPHL (NANOSEC)	3.32	3.12	3.22	3.00	3.50	2.65	3.40	6.40
TPHM (NANOSEC)	8.77	8.70	8.77	8.32	7.87	7.15	6.90	7.62
TPHM (NANOSEC)	9.22	8.72	8.62	8.42	8.12	7.22	6.80	7.65

THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDC

## MEASUREMENTS ON DEVICE NUMBER 2, DEVICE TYPE SN54500J

TEST	PRE RAD	.28E+13	.69E+14	.14E+15	.46E+15	.73E+15	.12E+16	.20E+16
VOL (VOLTS)	.4167	.4185	.4344	.4368	.4400	.5116	.5846	1.0380
VOM (VOLTS)	3.442	3.422	3.415	3.430	3.363	3.344	3.256	3.164
ICC (MILLIAMPS)	13.09	13.08	13.01	13.02	12.87	12.74	12.60	12.34
I <sub>OS</sub> (MILLIAMPS)	50.67	50.54	50.41	50.13	50.31	54.75	54.95	55.81
IIL (MILLIAMPS)	1.664	1.666	1.650	1.657	1.616	1.636	1.624	1.606
I <sub>TH</sub> (MICROAMPS)	.07	.05	.07	.09	.07	.09	.07	.07
TPHL (NANOSEC)	2.72	2.92	2.95	2.67	3.01	2.27	3.87	7.22
TPHL (NANOSEC)	3.17	3.25	3.22	3.27	3.42	2.67	3.80	7.57
TPLM (NANOSEC)	8.70	8.60	8.45	8.20	7.55	6.77	6.50	7.10
TPLM (NANOSEC)	8.70	8.65	8.37	8.00	7.91	6.95	6.80	7.22

THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDG

## MEASUREMENTS ON DEVICE NUMBER 3. DEVICE TYPE SN=4500J

TEST	PKE RAD	.28E+13	.69E+14	.14E+15	.46E+15	.73E+15	.12E+16	.20E+16
VOL (VOLTS)	.4144	.4195	.4302	.4367	.4339	.5211	.5841	1.6380
VOM (VOLTS)	3.472	3.449	3.434	3.459	3.461	3.389	3.318	3.232
ICC (MILLIAMPS)	11.63	11.59	11.51	11.56	11.43	11.32	11.20	11.00
IOS (MILLIAMPS)	50.84	50.73	50.60	50.34	50.60	54.93	55.17	55.94
IIL (MILLIAMPS)	1.475	1.466	1.450	1.469	1.457	1.449	1.437	1.420
IIM (MICROAMPS)	.08	.08	.09	.11	.11	.11	.10	.10
TPHL (NANOSEC)	3.05	3.07	3.07	2.72	3.10	2.50	3.62	6.32
TPHL (NANOSEC)	3.25	3.47	3.22	3.17	3.30	2.80	3.52	6.82
TPLM (NANOSEC)	8.97	8.80	8.52	8.17	7.92	7.17	6.85	7.32
TPLM (NANOSEC)	8.60	8.80	8.45	8.12	7.9	7.00	6.90	7.25



THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDC

## MEASUREMENTS ON DEVICE NUMBER 1, DEVICE TYPE SN64S74J

TEST	PRE PAD	.28E+13	.69E+14	.14E+15	.46E+15	.73E+15	.12E+16	.20E+16
VOL (VOLTS)	.4431	.4367	.4480	.4582	.5109	.5520	.6064	1.6380
VOL (VOLTS)	2.434	2.745	2.784	2.782	2.748	2.761	2.707	2.350
ICC (MILLIAMPS)	37.24	37.20	37.11	36.97	36.32	35.90	35.37	34.42
I <sub>CC</sub> (MILLIAMPS)	43.44	42.47	42.10	42.47	40.73	40.06	44.24	68.54
I <sub>IL</sub> (MILLIAMPS)	6.488	6.480	6.467	6.457	6.379	6.354	6.310	6.225
I <sub>IS</sub> (MICROAMPS)	.34	.37	.36	.28	.23	.16	.11	.10
T <sub>ONL</sub> (NSEC-CLOCK)	4.55	5.97	6.20	5.70	7.30	7.52	20.00	20.00
T <sub>ONL</sub> (NSEC-CLOCK)	13.57	13.30	13.27	14.75	14.15	11.52	6.22	9.65
T <sub>OFF</sub> (NSEC-CLOCK)	7.00	7.90	7.60	7.72	7.70	7.75	7.55	8.07
T <sub>OFF</sub> (NSEC-RESET)	13.42	13.45	13.02	14.17	13.25	11.67	10.97	10.92

THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDC

## MEASUREMENTS ON DEVICE NUMBER 2, DEVICE TYPE SN4574J

TEST	PPE RAD	.28E+13	.69E+14	.14E+15	.46E+15	.73E+15	.12E+16	.20E+16
VOL (VOLTS)	.4440	.4464	.4537	.4654	.5199	.5594	.6253	1.6380
VPH (VOLTS)	2.448	2.801	2.785	2.780	2.756	2.771	2.740	2.389
ICC (MILLIAMPS)	35.45	35.92	35.81	35.64	35.00	34.57	34.02	35.04
IOS (MILLIAMPS)	84.56	83.25	82.87	83.20	80.73	77.67	73.66	67.74
IIL (MILLIAMPS)	6.287	6.244	6.270	6.252	6.146	6.148	6.104	6.028
ITM (MICROAMPS)	.27	.26	.26	.23	.18	.13	.12	.10
TDEL (NSFC-CLOCK)	5.65	5.62	6.62	6.70	9.70	7.67	7.60	7.50
TDEL (NSFC-CLEAR)	13.42	13.72	13.65	14.65	14.27	12.65	6.42	12.72
TDEL (NSFC-CLOCK)	7.70	7.85	7.80	7.60	7.70	7.72	8.02	8.07
TDEL (NSFC-PRESET)	13.65	13.35	12.70	12.85	12.87	11.85	10.72	10.20

THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDC

## MEASUREMENTS ON DEVICE NUMBER 1, DEVICE TYPE SN=4LS00T

TEST	PRE RAD	.28E+13	.69E+14	.14E+15	.46E+15	.73E+15
VOL (VOLTS)	.3245	.3259	.3411	.3647	1.6380	1.6380
VOH (VOLTS)	3.580	3.577	3.566	3.535	3.440	3.351
ICC (MILLIAMPS)	.66	.66	.65	.64	.62	.61
IOS (MILLIAMPS)	14.46	14.46	14.28	14.13	13.56	12.92
IIL (MILLIAMPS)	.159	.159	.157	.156	.151	.148
ITH (MICROAMPS)	.40	.39	.39	.39	.35	.32
TPHL (NANOSEC)	14.15	14.40	15.12	16.07	20.17	25.37
TPHL (NANOSEC)	13.70	13.82	14.72	15.75	20.00	25.40
TPLH (NANOSEC)	16.92	16.92	17.07	17.32	18.42	19.90
TPLH (NANOSEC)	16.97	17.15	17.25	17.15	18.32	19.95

THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDC

## MEASUREMENTS ON DEVICE NUMBER 2, DEVICE TYPE SN=4LS00T

TEST	PRE PAD	.28E+13	.69E+14	.14E+15	.46E+15	.73E+15
VOL (VOLTS)	.3210	.3228	.3367	.3599	1.4230	1.6380
V <sub>OH</sub> (VOLTS)	3.591	3.580	3.577	3.547	3.475	3.388
I <sub>CC</sub> (MILLIAMPS)	.68	.68	.67	.67	.65	.63
I <sub>OS</sub> (MILLIAMPS)	14.59	14.59	14.44	14.29	13.77	13.19
I <sub>TL</sub> (MILLIAMPS)	.161	.162	.160	.159	.154	.150
I <sub>IH</sub> (MICROAMPS)	.03	.05	.06	.06	.07	.06
T <sub>DHL</sub> (NANOSEC)	14.25	14.15	14.77	15.82	18.95	23.87
T <sub>DHL</sub> (NANOSEC)	13.85	13.82	14.62	15.60	19.42	4.25
T <sub>D<sub>LH</sub></sub> (NANOSEC)	17.00	16.70	16.57	17.12	18.10	19.35
T <sub>D<sub>LH</sub></sub> (NANOSEC)	17.20	16.92	16.77	16.80	17.57	19.35

THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDG

MEASUREMENTS ON DEVICE NUMBER 3. DEVICE TYPE SN54LS00T

TEST	DEF PAD	.28E+13	.69E+14	.14E+15	.46E+15	.73E+15
VOL (VOLTS)	.2243	.3267	.3536	.3796	1.6380	1.6380
VOH (VOLTS)	3.582	3.578	3.564	3.532	3.439	3.341
IOL (MILLIAMPS)	.63	.64	.63	.62	.60	.59
IOS (MILLIAMPS)	14.27	14.22	14.14	13.99	13.40	12.79
TIH (MILLIAMPS)	.152	.153	.151	.150	.145	.142
TIH (MICROAMPS)	.06	.06	.06	.05	.05	.05
TOHL (NANOSEC)	14.47	14.70	15.52	16.35	20.90	26.60
TOHL (NANOSEC)	14.07	14.32	15.27	15.95	21.07	26.65
TOIH (NANOSEC)	17.65	17.32	17.67	17.65	18.90	20.67
TOIH (NANOSEC)	17.52	17.42	17.67	17.62	18.90	20.92



THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDG

## MEASUREMENTS ON DEVICE NUMBER 4, DEVICE TYPE SN54LS00T

TEST	PPF PAD	.28E+13	.69E+14	.14E+15	.46E+15	.73E+15
VOL (VOLTS)	.3321	.3335	.3516	.3719	1.6120	1.6380
VOL (VOLTS)	3.569	3.564	3.547	3.524	3.428	3.318
ICC (MILLIAMPS)	.69	.70	.69	.68	.64	.65
IOS (MILLIAMPS)	14.80	14.80	14.63	14.51	13.86	13.12
TIH (MILLIAMPS)	.168	.169	.167	.166	.141	.157
TIH (MICROAMPS)	.03	.05	.03	.04	.05	.06
TDHL (NANOSEC)	14.20	14.42	14.92	16.11	20.12	26.15
TDHL (NANOSEC)	13.50	14.05	14.85	15.92	20.25	26.22
TOLH (NANOSEC)	16.85	16.52	16.70	16.52	18.35	19.95
TOLH (NANOSEC)	16.70	16.75	16.80	16.90	18.10	19.85

THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDC

## MEASUREMENTS ON DEVICE NUMBER 5, DEVICE TYPE SN54LS00T

TEST	PRE PAD	.28E+13	.69E+14	.14E+15	.46E+15	.73E+15
VOL (VOLTS)	.3175	.3196	.3342	.3553	.4435	1.6380
VOM (VOLTS)	3.591	3.582	3.574	3.554	3.470	3.395
ICC (MILLIAMPS)	.70	.71	.70	.69	.68	.66
IOS (MILLIAMPS)	14.59	14.62	14.46	14.33	13.82	13.28
IIL (MILLIAMPS)	.168	.169	.166	.166	.161	.157
ITH (MICROAMPS)	.07	.04	.06	.06	.07	.07
TPHL (NANOSEC)	13.92	13.95	14.47	15.27	18.52	23.12
TPHL (NANOSEC)	13.32	13.40	14.10	15.05	18.45	23.52
TPLH (NANOSEC)	17.10	17.25	17.15	17.45	18.30	18.97
TPLH (NANOSEC)	17.52	17.35	17.50	17.02	17.72	19.42

THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDC

## MEASUREMENTS ON DEVICE NUMBER 1, DEVICE TYPE SN=4LS74J

TEST	PPE PAD	.28E+13	.69E+14	.14E+15	.46E+15	.73E+15
VOL (VOLTS)	.2647	.2800	.3191	.3709	1.5380	1.6380
VOM (VOLTS)	3.442	3.427	3.397	3.400	3.233	3.119
ICC (MILLIAMPS)	4.58	4.58	4.51	4.48	4.33	4.22
IOS (MILLIAMPS)	18.96	18.89	18.35	17.88	15.77	10.46
IIL (MILLIAMPS)	1.055	1.055	1.047	1.043	1.021	1.000
IIM (MICROAMPS)	.61	.60	.24	.19	.17	.15
TDHL (NSFC-CLOCK)	26.72	26.80	26.80	27.60	37.00	42.50
TDHL (NSEC-CLEAR)	32.57	32.32	31.90	34.47	45.40	55.00
TDLM (NSFC-CLOCK)	22.30	20.40	18.90	19.70	28.20	33.00
TDLM (NSFC-PRESET)	27.30	26.60	23.80	24.00	26.60	27.47

THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDC

## MEASUREMENTS ON DEVICE NUMBER 2, DEVICE TYPE SN54LS74J

TEST	PWE PAD	.28E+13	.69E+14	.14E+15	.46E+15	.73E+15
VOL (VOLTS)	.2800	.2924	.3332	.3845	1.6180	1.6380
VTH (VOLTS)	3.439	3.425	3.393	3.391	3.253	3.116
ICC (MILLIAMPS)	4.55	4.55	4.49	4.46	4.32	4.21
IOS (MILLIAMPS)	17.67	17.64	17.13	16.68	14.57	10.13
IIL (MILLIAMPS)	1.039	1.039	1.036	1.035	1.017	.996
IFM (MICROAMPS)	.62	.57	.47	.39	.29	.15
TDEL (NSFC-CLOCK)	27.45	27.40	26.17	27.10	35.90	43.80
TDEL (NSFC-CLFAR)	32.75	32.82	34.60	34.27	43.90	55.57
TPLH (NSFC-CLOCK)	23.40	21.60	19.00	19.10	27.80	32.32
TPLH (NSFC-PRESET)	27.40	28.30	24.50	25.30	26.70	27.00

THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDC

## MEASUREMENTS ON DEVICE NUMBER 3, DEVICE TYPE SN=4LS74J

TEST	PPE PAU	.28E+13	.69E+14	.14E+15	.46E+15	.73E+15
VOL (VOLTS)	.2390	.2509	.2778	.3107	1.6280	1.6380
VOL (VOLTS)	3.466	3.455	3.428	3.441	3.345	3.316
ICC (MILLIAMPS)	4.60	4.59	4.55	4.50	4.33	4.27
IOS (MILLIAMPS)	17.34	17.32	16.77	16.38	14.75	13.78
IIL (MILLIAMPS)	1.017	1.017	1.017	1.016	1.007	.983
IIF (MICROAMPS)	1.50	1.34	1.29	1.14	1.10	.61
TDEL (NSEC-CLOCK)	26.10	26.15	25.60	26.05	31.50	36.25
TDEL (NSEC-CLEAR)	33.62	33.80	32.55	33.62	29.02	43.00
TPLM (NSEC-CLOCK)	23.50	22.50	20.70	20.70	24.10	29.70
TPLM (NSEC-PRESET)	28.90	28.30	25.20	24.80	25.50	25.82



THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDG

## MEASUREMENTS ON DEVICE NUMBER 4. DEVICE TYPE SN54LS74J

TEST	PRE RAD	.28E+13	.69E+14	.14E+15	.46E+15	.73E+15
VOL (VOLTS)	.2392	.2485	.2747	.3089	1.6380	1.6380
V <sub>OH</sub> (VOLTS)	3.466	3.448	3.427	3.434	3.375	3.321
I <sub>CC</sub> (MILLIAMPS)	4.62	4.62	4.56	4.53	4.40	4.28
I <sub>OS</sub> (MILLIAMPS)	17.30	17.27	16.74	16.32	14.68	13.70
I <sub>OL</sub> (MILLIAMPS)	1.024	1.026	1.022	1.025	1.018	.996
I <sub>IL</sub> (MICROAMPS)	.32	.27	1.25	1.07	.96	.58
T <sub>DEL</sub> (NSEC-CLOCK)	23.00	21.50	19.30	18.30	22.90	28.60
T <sub>DEL</sub> (NSEC-CLEAR)	32.10	32.00	31.15	33.95	38.20	42.20
T <sub>FLM</sub> (NSEC-CLOCK)	24.72	24.30	23.30	24.10	30.70	35.02
T <sub>FLM</sub> (NSEC-PRESET)	28.30	28.10	25.40	25.20	25.90	25.75

THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDC

## MEASUREMENTS ON DEVICE NUMBER 1, DEVICE TYPE 950859

TEST	PRE	PA0	.28E+13	.69E+14	.14E+15	.46E+15	.73E+15
VOL (VOLTS)	-1.732	-1.747	-1.733	-1.708	-1.647	-1.525	
V0H (VOLTS)	-.939	-.955	-.960	-.954	-.971	-.991	
ICC (MILLIAMPS)	71.53	71.13	69.69	69.24	67.50	60.48	
ITL (MILLIAMPS)	1.91	1.81	1.80	1.82	1.83	1.86	
ITM (MILLIAMPS)	2.25	2.25	2.25	2.27	2.30	2.40	
TOHL (NSFC-CLOCK)	3.75	3.15	3.32	3.55	2.27	1.70	
TOPL (NSFC-CLEAR)	3.60	3.95	3.97	4.02	3.07	2.42	
TPLH (NSFC-CLOCK)	4.02	4.42	4.40	4.37	3.45	2.28	
TOLH (NSFC-PRESET)	7.52	4.82	4.62	5.62	3.85	2.97	

THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDC

## MEASUREMENTS ON DEVICE NUMBER 2, DEVICE TYPE 950859

TEST	DPE 0A0	.28E+13	.69E+14	.14F+15	.46E+15	.73E+15
VOL (VOLTS)	-1.740	-1.736	-1.718	-1.684	-1.592	-1.434
VOL (VOLTS)	-.043	-.956	-.963	-.974	-.905	-1.058
ICC (MILLIAMPS)	65.69	63.16	61.70	60.68	61.10	48.96
ITL (MILLIAMPS)	1.83	1.77	1.77	1.79	1.84	1.91
ITT (MILLIAMPS)	2.24	2.20	2.21	2.24	2.33	2.48
TOTL (NSEC-CLOCK)	3.67	3.52	3.60	4.05	2.45	1.52
TOTL (NSEC-CLEAR)	4.20	4.10	4.10	4.20	2.85	4.00
TOTL (NSEC-CLOCK)	4.60	4.62	4.35	4.25	2.70	1.80
TOTL (NSEC-PRESET)	5.42	5.40	4.72	4.55	3.20	3.07

THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDC

## MEASUREMENTS ON DEVICE NUMBER 3, DEVICE TYPE 950859

TEST	PRE	13	14	15	15
	PAD	.28E+13	.69E+14	.14E+15	.73E+15
VOL (VOLTS)	-1.745	-1.734	-1.716	-1.681	-1.599
VOL (VOLTS)	-.958	-.957	-.960	-.964	-.948
ICC (MILLIAMPS)	66.43	64.96	63.75	63.53	63.47
ITL (MILLIAMPS)	1.79	1.83	1.84	1.86	1.87
ITL (MILLIAMPS)	1.09	2.29	2.30	2.33	2.39
TOHL (NSFC-CLOCK)	4.32	3.37	3.50	3.67	2.32
TOHL (NSFC-CLEAR)	4.10	3.75	3.95	4.02	2.75
TOHL (NSFC-CLOCK)	4.62	4.72	4.42	4.37	2.77
TOHL (NSFC-PRESET)	5.30	5.02	4.67	4.50	3.32

THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDC

## MEASUREMENTS ON DEVICE NUMBER 1. DEVICE TYPE MC10131L

TEST	PRE PAD	.28E+13	.69E+14	.14E+15	.46E+15	.73E+15
VOL (VOLTS)	-1.753	-1.753	-1.753	-1.717	-1.462	-1.592
VOL (VOLTS)	-.866	-.873	-.906	-.907	-.909	-1.056
ICC (MILLIAMPS)	35.94	35.71	34.50	34.22	32.53	31.09
ITI (MICROAMPS)	16.00	16.37	27.50	39.18	75.22	133.02
ITH (MILLIAMPS)	.02	.02	.03	.05	.10	.12
T0HL (NSFC-CLOCK)	3.35	2.57	3.12	4.05	2.62	2.32
T0HL (NSFC-CLFAR)	3.35	3.67	3.92	4.65	3.72	3.27
T0LH (NSFC-CLOCK)	5.65	5.70	5.07	5.17	4.23	3.65
T0LH (NSFC-PRESET)	5.52	5.30	5.17	5.32	3.95	3.67



THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDC

## MEASUREMENTS ON DEVICE NUMBER 2, DEVICE TYPE MC10131L

TEST	PRE PAD	.28E+13	.69E+14	.14E+15	.46E+15	.73E+15
VOL (VOLTS)	-1.759	-1.760	-1.759	-1.727	-1.453	-1.608
VOL (VOLTS)	-.870	-.873	-.913	-.919	-.920	-1.115
ICC (MILLIAMPS)	35.71	35.48	34.28	34.00	32.02	30.90
ITL (MICROAMPS)	18.82	19.82	30.41	41.23	70.32	131.15
ITL (MILLIAMPS)	.02	.02	.03	.04	.02	.11
TOHL (NSFC-CLOCK)	2.87	2.70	3.50	3.87	2.45	2.30
TOHL (NSFC-CLEAR)	3.32	3.87	4.00	4.75	3.42	3.32
TOHL (NSFC-CLOCK)	5.72	5.75	5.35	5.17	4.15	3.77
TOHL (NSFC-PRESET)	5.86	5.35	5.40	5.40	4.02	3.80

THIS PAGE IS BEST QUALITY PRACTICABLE  
FROM COPY FURNISHED TO DDC

## MEASUREMENTS ON DEVICE NUMBER 3, DEVICE TYPE MC10131L

TEST	DPE PAD	.24E+13	.69E+14	.14E+15	.46E+15	.73E+15
V <sub>M</sub> (VOLTS)	-1.721	-1.721	-1.713	-1.679	-1.606	-1.557
V <sub>DD</sub> (VOLTS)	-0.912	-0.917	-0.954	-0.967	-1.068	-1.130
I <sub>CC</sub> (MILLIAMPS)	36.97	36.77	35.40	34.96	32.53	30.73
I <sub>TL</sub> (MICROAMPS)	60.65	62.56	77.06	93.83	150.69	239.86
I <sub>TH</sub> (MILLIAMPS)	.02	.04	.09	.11	.17	.21
T <sub>DEL</sub> (NSEC-CLOCK)	3.17	3.02	3.60	4.22	2.72	2.20
T <sub>DEL</sub> (NSEC-CLEAR)	3.42	3.67	3.50	4.72	3.75	3.10
T <sub>DEL</sub> (NSEC-CLOCK)	5.52	5.60	5.40	5.12	4.07	3.25
T <sub>TH</sub> (NSEC-PRESET)	5.47	5.47	5.37	5.27	4.42	3.42

## DISTRIBUTION LIST

### DEPARTMENT OF DEFENSE

Director  
Armed Forces Radiobiology Research Institute  
Defense Nuclear Agency  
National Naval Medical Center  
ATTN: Technical Library

Commander in Chief  
U.S. European Command  
ATTN: FCJ6-PF

Defense Communication Engineer Center  
ATTN: Code R320, C. Bergman  
ATTN: Code R410, J. McLean

Director  
Defense Communications Agency  
ATTN: Code 930, M. Burgett, Jr.

Defense Documentation Center  
Cameron Station  
12 cy ATTN: TC

Director  
Defense Intelligence Agency  
ATTN: DS-4A2

Director  
Defense Nuclear Agency  
ATTN: TITL  
ATTN: DDST  
ATTN: RAEV

Commander  
Field Command  
Defense Nuclear Agency  
ATTN: FCPR

Director  
Interservice Nuclear Weapons School  
ATTN: Document Control

Director  
Joint Strat. Tgt. Planning Staff  
ATTN: JLTW-2

Chief  
Livermore Division, Fld. Command, DNA  
Lawrence Livermore Laboratory  
ATTN: FCPRL

Director  
National Security Agency  
ATTN: D. Vincent  
ATTN: TDL  
ATTN: O. Van Gunten, R-425

OJCS/J-3  
ATTN: J-3, RDTA, BR, WWMCCS, Plans Div.

Under Secretary of Def. for Rsch. & Engrg.  
ATTN: S&SS (OS)  
ATTN: AE

### DEPARTMENT OF THE ARMY

Project Manager  
Army Tactical Data Systems  
U.S. Army Electronics Command  
ATTN: D. Huewe  
ATTN: DRCPN-TDS-SD

Commander  
BMD System Command  
ATTN: BDMSC-TEN, N. Hurst

Commander  
ERADCOM Technical Support Directorate  
ATTN: DRSEL-GG-TD, W. Werk  
ATTN: DRSEL-CT-HDK, A. Cohen  
ATTN: DRSEL-CE, T. Preiffer  
ATTN: DRSEL-PL-ENV, H. Bomke  
ATTN: DRSEL-TL-TR, E. Hunter  
ATTN: DRSEL-TL-MD, G. Gaule  
ATTN: DRSEL-TL-ND, S. Kronenbey

Commander  
Harry Diamond Laboratories  
ATTN: DELHD-RCC, J. Rosado  
ATTN: DELHD-RCC, J. Thompson  
ATTN: DELHD-TI, Tech. Lib.  
ATTN: DELHD-EM, R. McCoskey  
ATTN: DELHD-TF, R. Oswald, Jr.  
ATTN: DELHD-EM, R. Bostak  
ATTN: DELHD-EM, J. McGarrity  
ATTN: DELHD-EM, J. Halpin  
ATTN: DELHD-RB, J. Mileta  
ATTN: DELHD-EM, J. Reilfuss  
ATTN: DELHD-NP, F. Wimenitz  
ATTN: DELHD-EM, R. Gray  
ATTN: DELHD-EM, R. Wong

Commanding Officer  
Night Vision Laboratory  
U.S. Army Electronics Command  
ATTN: CPT A. Parker

Commander  
Redstone Scientific Information Ctr.  
U.S. Army Missile Command  
3 cy ATTN: Chief, Documents

Secretary of the Army  
ATTN: ODUSA or D. Willard

Director  
TRASANA  
ATTN: ATAA-EAC, F. Winans

Director  
U.S. Army Ballistic Research Labs.  
ATTN: DRXBR-VL, J. Kinch  
ATTN: DRXBR-X, J. Meszaros  
ATTN: DRXBR-AM, W. Vanantwerp  
ATTN: DRXBR-VL, R. Harrison  
ATTN: DRXBR-BYL, D. Rigotti

Chief  
U.S. Army Communications Sys. Agency  
ATTN: SCCM-AD-SV, Library

DEPARTMENT OF THE ARMY (Continued)

Commander  
U.S. Army Electronics Proving Ground  
ATTN: STEEP-MT-M, G. Durbin

Commandant  
U.S. Army Engineer School  
ATTN: ATSE-CTD-CS, S. Grazier

Commander-in-Chief  
U.S. Army Europe and Seventh Army  
ATTN: ODCSE-E, AFAGF-PI

Commandant  
U.S. Army Field Artillery School  
ATTN: ATSFA-CTD-ME, H. Moberg

Commander  
U.S. Army Mat. & Mechanics Rsch. Ctr.  
ATTN: DRXMR-HH, J. Dignam

Commander  
U.S. Army Materiel Dev. & Readiness Cmd.  
ATTN: DRCDE-D, L. Flynn

Commander  
U.S. Army Missile R&D Command  
ATTN: DRCPM-PE-EA, W. Wagner  
ATTN: DRSMI-RGD, V. Ruwe  
ATTN: DRSMI-RGP, H. Green

Chief  
U.S. Army Nuc. and Chemical Surety Gp.  
ATTN: MOSG-ND, MAJ S. Winslow

Commander  
U.S. Army Nuclear & Chemical Agency  
ATTN: Library

Commander  
U.S. Army Tank Automotive Command  
ATTN: DRCPM-GCM-SW, L. Wolcott

Commander  
U.S. Army Test and Evaluation Comd.  
ATTN: DRSTE-EL, R. Kolchin  
ATTN: DRSTE-NB, R. Galasso

Commander  
White Sands Missile Range  
ATTN: STEWS-TE-NT, M. Squires

DEPARTMENT OF THE NAVY

Chief of Naval Research  
ATTN: Code 427

Commanding Officer  
Naval Avionics Facility  
ATTN: Branch 942, D. Repass

Commander  
Naval Electronic Systems Command  
Naval Electronic Systems Cmd. Hqs.  
ATTN: Code 5032, C. Neill  
ATTN: ELEX 05323, C. Watkins  
ATTN: PME 117-21  
ATTN: Code 504511, C. Suman  
ATTN: Code 50451

DEPARTMENT OF THE NAVY (Continued)

Commanding Officer  
Naval Intelligence Support Ctr.  
ATTN: NISC-45

Commander  
Naval Ocean Systems Center  
ATTN: H. Wong

Director  
Naval Research Laboratory  
ATTN: Code 5210, J. Davey  
ATTN: Code 2627, D. Folen  
ATTN: Code 4104, E. Brancato  
ATTN: Code 5580, G. Sigel  
ATTN: Code 5216, H. Hughes  
ATTN: Code 601, F. Wolicki  
ATTN: Code 6701, J. Brown  
ATTN: Code 6631, J. Ritter

Commander  
Naval Sea Systems Command  
ATTN: SEA-9931, R. Lane  
ATTN: SEA-9931, S. Barham

Officer-in-Charge  
Naval Surface Weapons Center  
ATTN: Code WA501, Navy Nuc. Prgms. Off.  
ATTN: Code WA52, R. Smith  
ATTN: Code WA50

Commander  
Naval Surface Weapons Center  
Dahlgren Laboratory  
ATTN: Code FUR, R. Amadori

Commander  
Naval Weapons Center  
ATTN: Code 533, Tech. Lib.

Commanding Officer  
Naval Weapons Evaluation Facility  
ATTN: Code ATG, Mr. Stanley

Commanding Officer  
Naval Weapons Support Center  
ATTN: Code 7024, J. Ramsey  
ATTN: Code 70242, J. Numarin

Commanding Officer  
Nuclear Weapons Tng. Center, Pacific  
Naval Air Station, North Island  
ATTN: Code 50

Director  
Strategic Systems Project Office  
ATTN: NSP-2342, R. Coleman  
ATTN: SP 2701, J. Pitsenberger  
ATTN: NSP-27331, P. Spector

DEPARTMENT OF THE AIR FORCE

AF Aero-Propulsion Laboratory, AFSC  
ATTN: POD, P. Stover

AF Institute of Technology, AU  
ATTN: ENP, C. Bridgman

AF Materials Laboratory, AFSC  
ATTN: LTE



DEPARTMENT OF THE AIR FORCE (Continued)

AF Weapons Laboratory, AFSC

ATTN: ELS  
ATTN: ELA  
ATTN: ELP, Tree Section  
ATTN: NT, C. Baum  
ATTN: ELP, J. Nichols  
ATTN: NTS  
ATTN: ELXT  
ATTN: DEX  
2 cy ATTN: SUL  
ATTN: HO, Dr. Minge  
10 cy ATTN: ELP, Lt M. Knoll, Project Officer

AFTAC

ATTN: TFS, Maj M. Schneider  
ATTN: TAE

Air Force Avionics Laboratory, AFSC

ATTN: AAT, M. Friar  
ATTN: DHM, C. Friend  
ATTN: DH, Lt Col McKenzie  
ATTN: DHE, H. Hennecke

Commander

ASD

ATTN: ASD/ENESS, P. Marth  
ATTN: ASD-YH-EX, Lt Col R. Leverette  
ATTN: ENACC, R. Fish

Headquarters

Electronic Systems Division/YSEA  
ATTN: YSEA

Headquarters

Electronic Systems Division/YW  
ATTN: YWEI

Commander

Foreign Technology Division, AFSC

ATTN: FTD/PDJC  
ATTN: ETDp

Commander

Ogden ALC/MMEDDE

ATTN: MMETH, R. Joffs

Commander

Rome Air Development Center, AFSC

ATTN: RBRAC, I. Krulac  
ATTN: RBRP, C. Lane

Commander

Rome Air Development Center, AFSC

ATTN: ESR, B. Buchanan  
ATTN: ESD, A. Kahan  
ATTN: ETS, R. Dolan

SAMSO/DY

ATTN: DYS, Capt E. Merz

SAMSO/MN

ATTN: MNNH

SAMSO/RS

ATTN: RSMG, Capt Collier  
ATTN: RSSE, Lt Col K. Gilbert

SAMSO/SK

ATTN: SKE, P. Stadler

DEPARTMENT OF THE AIR FORCE (Continued)

SAMSO/SZ

ATTN: SZJ, Capt J. Salch

Commander in Chief

Strategic Air Command

ATTN: XPFS, Maj B. Stephan  
ATTN: NRI-STINFO, Library

Air University Library

ATTN: LDE

DEPARTMENT OF ENERGY

Department of Energy

Albuquerque Operations Office

ATTN: Document Control for WSSB

University of California

Lawrence Livermore Laboratory

ATTN: R. Ott, L-531  
ATTN: W. Hogan, L-389  
ATTN: J. Keller, Jr., L-125  
ATTN: F. Kovar, L-31  
ATTN: D. Meeker, L-545  
ATTN: E. Miller, L-156  
ATTN: Tech. Info., Dept. L-3  
ATTN: H. Kruger, L-96  
ATTN: L. Cleland, L-156

Los Alamos Scientific Laboratory

ATTN: Doc. Con. for B. Noel  
ATTN: Doc. Con. for J. Freed

Sandia Laboratories

ATTN: Doc. Con. for Org. 2110, J. Hood  
ATTN: Doc. Con. for 3141, Sandia Rpt. Coll.  
ATTN: Doc. Con. for Org. 2140, R. Gregory

OTHER GOVERNMENT AGENCY

Department of Commerce

National Bureau of Standards

ATTN: J. French

DEPARTMENT OF DEFENSE CONTRACTORS

Aerojet Electro-Systems Co.

Div. of Aerojet-General Corporation

ATTN: T. Hanscome

Aerospace Corporation

ATTN: J. Reinheimer  
ATTN: I. Garfunkel  
ATTN: S. Bower  
ATTN: Library  
ATTN: L. Aukerman  
ATTN: J. Ditre  
ATTN: W. Willis

Avco Research & Systems Group

ATTN: Research Lib. A830, Rm. 7201

The BDM Corporation

ATTN: D. Alexander

The Bendix Corporation

Communication Division

ATTN: Document Control



AD-A058 093

AIR FORCE WEAPONS LAB KIRTLAND AFB N MEX  
COMPARISON STUDY OF THE FIVE TRANSISTOR-TRANSISTOR-LOGIC (TTL) --ETC(U)  
MAY 78 M G KNOLL  
AFWL-TR-78-5

F/G 9/5

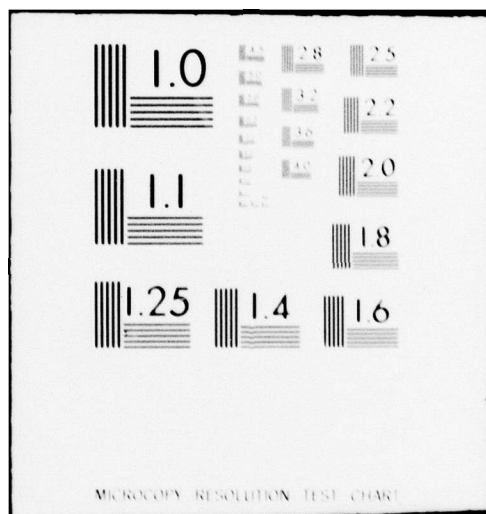
UNCLASSIFIED

NL

2 of 2  
AD  
A058 093



END  
DATE  
FILMED  
10-78  
DDC



DEPARTMENT OF DEFENSE CONTRACTORS (Continued)

The Bendix Corporation  
Research Laboratories Division  
Bendix Center

ATTN: Mgr. Prgm. Dev., D. Niehaus  
ATTN: M. Frank

The Boeing Company

ATTN: H. Wicklein, MS 17-11  
ATTN: Aerospace Library  
ATTN: D. Egelkrout, MS 2R-00  
ATTN: I. Amura, 2R-00  
ATTN: R. Caldwell, 2R-00  
ATTN: C. Rosenbert, 2R-00

Booz-Allen and Hamilton, Inc.

ATTN: R. Chrisner

California Institute of Technology

Jet Propulsion Laboratory

ATTN: J. Bryden  
ATTN: A. Stanley

Charles Stark Draper Laboratory, Inc.

ATTN: P. Kelly  
ATTN: K. Fertig

Cincinnati Electronics Corporation

ATTN: C. Stump  
ATTN: L. Hammond

Control Data Corporation

ATTN: J. Meehan

Cutler-Hammer, Inc.

Ail Division

ATTN: Central Tech. Files, A. Anthony

University of Denver

Colorado Seminary

Denver Research Institute

ATTN: Sec. Officer for F. Venditti

Dikewood Industries, Inc.

ATTN: L. Davis

E-Systems, Inc.

Greenville Division

ATTN: Library 8-50100

Effects Technology, Inc.

ATTN: E. Steele

EXP & Math Physics Consultants

ATTN: T. Jordan

Fairchild Camera and Instrument Corp.

ATTN: Sec. Dept. for 2-233, D. Myers

Fairchild Industries, Inc.

Sherman Fairchild Technology Center

ATTN: Mgr. Config. Data & Standards

University of Florida

ATTN: P. Rambo for D. Kennedy

Ford Aerospace & Communications Corp.

ATTN: D. McMorrow, MS G30  
ATTN: E. Hahn, MS-X22  
ATTN: S. Crawford, MS 531

DEPARTMENT OF DEFENSE CONTRACTORS (Continued)

Ford Aerospace & Communications Operations

ATTN: Tech. Info. Section

ATTN: K. Attinger

ATTN: F. Poncelet, Jr.

The Franklin Institute

ATTN: R. Thompson

Garrett Corporation

ATTN: R. Weir, Dept. 93-9

General Electric Company

Space Division

Valley Forge Space Center

ATTN: L. Chasen

ATTN: J. Peden, VFSC, Rm. 4230M

ATTN: J. Andrews

General Electric Company

Re-Entry & Environmental Systems Div.

ATTN: R. Benedict

ATTN: W. Patterson

ATTN: J. Palcheesky, Jr.

General Electric Company

Ordnance Systems

ATTN: J. Reid

General Electric Company

TEMPO-Center for Advanced Studies

ATTN: M. Espig

ATTN: W. McNamera

ATTN: R. Rutherford

ATTN: DASIAC

General Electric Company

Aircraft Engine Business Group

ATTN: J. Ellerhorst, E2

General Electric Company

Aerospace Electronics Systems

ATTN: C. Hewison, Drop 624

General Electric Company

ATTN: D. Pepin, Drop 160

General Electric Company-TEMPO

ATTN: DASIAC for W. Alfante

General Research Corporation

ATTN: R. Hill

Georgia Institute of Technology

Georgia Tech. Research Institute

ATTN: R. Curry

Grumman Aerospace Corporation

ATTN: J. Rogers, Dept. 533

GTE Sylvania, Inc.

Electronics Systems Grp.-Eastern Div.

ATTN: C. Thornhill, Librarian

ATTN: L. Blaisdell

ATTN: J. Waldon

GTE Sylvania, Inc.

ATTN: H & V Group

ATTN: P. Fredrickson

ATTN: J. Waldron

ATTN: H. Ullman

ATTN: C. Ramsbottom

DEPARTMENT OF DEFENSE CONTRACTORS (Continued)

Gulton Industries, Inc.  
Engineered Magnetics Division  
ATTN: Engnmagnetics Div.

Harris Corporation  
Harris Semiconductor Division  
ATTN: T. Clark, MS 4040

Hazeltine Corporation  
ATTN: Tech. Info. Ctr., M. Waite

Honeywell Incorporated  
Avionics Division  
ATTN: R. Johnson, A1622  
ATTN: R. Kell, MS S2572

Honeywell Incorporated  
Avionics Division  
ATTN: S. Graff, MS 725-5  
ATTN: H. Noble, MS 725-5A

Honeywell Incorporated  
Radiation Center  
ATTN: Technical Library

Hughes Aircraft Company  
ATTN: K. Walker, MS Dis7  
ATTN: B. Campbell, MS 6-E-110  
ATTN: D. Binder, MS 6-D147  
ATTN: J. Singletary, MS 6-D133

Hughes Aircraft Company  
El Segundo Site  
ATTN: E. Smith, MS A620  
ATTN: W. Scott, MS A1080

IBM Corporation  
ATTN: F. Frankovsky  
ATTN: H. Mathers, Dept. M41

IIT Research Institute  
ATTN: I. Mindel

Intl. Tel. & Telegraph Corporation  
ATTN: A. Richardson

Ion Physics Corporation  
ATTN: R. Evans

IRT Corporation  
ATTN: MDC  
ATTN: R. Mertz

JAYCOR  
ATTN: E. Wenaas

JAYCOR  
ATTN: R. Sullivan  
ATTN: C. Turesko

Johns Hopkins University  
Applied Physics Laboratory  
ATTN: P. Partridge

Kaman Sciences Corporation  
ATTN: A. Bridges  
ATTN: J. Hoffman  
ATTN: D. Bryce  
ATTN: J. Lubell  
ATTN: W. Rich  
ATTN: W. Ware

DEPARTMENT OF DEFENSE CONTRACTORS (Continued)

Litton Systems, Inc.  
Guidance & Control Systems Division  
ATTN: R. Maughmer  
ATTN: J. Retzler  
ATTN: V. Ashby, MS 67  
ATTN: W. Mras

Litton Systems, Inc.  
Electron Tube Division  
ATTN: F. McCarthy

Lockheed Missiles & Space Co., Inc.  
ATTN: B. Kimura, Dept. 81-14  
ATTN: G. Heath, D/81-14  
ATTN: E. Smith, D/85-85  
ATTN: S. Taimuty, D/85-85  
ATTN: L. Rossi, D/81-64

Lockheed Missiles and Space Co., Inc.  
ATTN: Tech. Info. Ctr., D/Coll.

M.I.T. Lincoln Laboratory  
ATTN: L. Loughlin, Librarian A-082

Martin Marietta Corporation  
Orlando Division  
ATTN: J. Ashford, MP-537  
ATTN: M. Griffith, Lib. MP-30

Martin Marietta Corporation  
Denver Division  
ATTN: B. Graham, MS PO-454  
ATTN: P. Kase, Mail 8203  
ATTN: Research Lib. 6617, J. McKee  
ATTN: J. Goodwin, Mail 0452

McDonnell Douglas Corporation  
ATTN: Technical Library  
ATTN: T. Ender

McDonnell Douglas Corporation  
ATTN: S. Schneider

McDonnell Douglas Corporation  
ATTN: Technical Library, C1-290/36-84

Mission Research Corporation  
ATTN: W. Hart

Mission Research Corporation  
EM System Applications Division  
ATTN: D. Merewether

Mission Research Corporation-San Diego  
ATTN: J. Raymond  
ATTN: V. Van Lint

The Mitre Corporation  
ATTN: M. Fitzgerald

National Academy of Sciences  
ATTN: National Materials Advisory Board for  
R. Shane, Nat. Materials Advsy.

University of New Mexico  
Electrical Engineering & Computer Science Dept.  
ATTN: H. Southward

Northrop Corporation  
Electronic Division  
ATTN: G. Towner

DEPARTMENT OF DEFENSE CONTRACTORS (Continued)

Northrop Corporation  
Northrop Research and Technology Ctr.  
ATTN: O. Curtis, Jr.  
ATTN: J. Srouer  
ATTN: D. Pocock

Northrop Corporation  
Electronic Division  
ATTN: J. Russo  
ATTN: V. Demartino  
ATTN: R. Ahlport

Palisades Inst. for Rsch. Services, Inc.  
ATTN: Records Supervisor

Physics International Company  
ATTN: Doc. Con. for C Stallings  
ATTN: Doc. Con. for J. Huntington

R & D Associates  
ATTN: S. Rogers

The Rand Corporation  
ATTN: C. Crain

Raytheon Company  
ATTN: G. Joshi, Radar Sys. Lab.

Raytheon Company  
ATTN: H. Flescher

RCA Corporation  
Government Systems Division  
Astro Electronics  
ATTN: G. Brucker

RCA Corporation  
Camden Complex  
ATTN: E. Van Keuren, 13-5-2

Rensselaer Polytechnic Institute  
ATTN: R. Gutmann

Research Triangle Institute  
ATTN: Eng. Div., M. Simons, Jr.

Rockwell International Corporation  
ATTN: K. Hull  
ATTN: N. Rudie, FA53  
ATTN: D. Stevens, FA70  
ATTN: G. Messenger, FB61  
ATTN: J. Bell, HA10

Rockwell International Corporation  
ATTN: T. Yates

Rockwell International Corporation  
Collins Divisions  
ATTN: A. Langenfeld

Sanders Associates, Inc.  
ATTN: M. Aitel, NCA 1-3236

Science Applications, Inc.  
ATTN: W. Chadsey

Science Applications, Inc.  
ATTN: F. Tesche

DEPARTMENT OF DEFENSE CONTRACTORS (Continued)

Science Applications, Inc.  
ATTN: J. Beyster

Science Applications, Inc.  
Huntsville Division  
ATTN: N. Byrn

Science Applications, Inc.  
ATTN: J. Hill

The Singer Company (Data Systems)  
ATTN: Tech. Info. Center

The Singer Company  
ATTN: Security Manager for I. Goldman,  
Eng. Management

Sperry Flight Systems Division  
Sperry Rand Corporation  
ATTN: D. Schow

Sperry Rand Corporation  
Sperry Division  
ATTN: P. Maraffino  
ATTN: C. Craig, EV

Sperry Univac  
ATTN: J. Inda, MS 41T25

SRI International  
ATTN: P. Dolan  
ATTN: A. Whitson

SRI International  
ATTN: M. Morgan

Sundstrand Corporation  
ATTN: C. White

Systron-Donner Corporation  
ATTN: G. Dean  
ATTN: H. Morris

Texas Instruments, Inc.  
ATTN: D. Manus, MS 72

Texas Tech University  
ATTN: T. Simpson

TRW Defense & Space Sys. Group  
One Space Park  
2 cy ATTN: R. Plebuch, R1-2078  
ATTN: H. Holloway, R1-2036  
ATTN: Tech. Info. Center/S-1930  
2 cy ATTN: O. Adams, R1-1144

TRW Defense & Space Sys. Group  
San Bernardino Operations  
ATTN: F. Fay  
ATTN: R. Kitter

United Technologies Corporation  
Hamilton Standard Division  
ATTN: R. Giguere

Vought Corporation  
ATTN: Technical Data Ctr.

Westinghouse Electric Corporation  
Defense and Electronic Systems Ctr.  
ATTN: H. Kalapaca, MS 3525